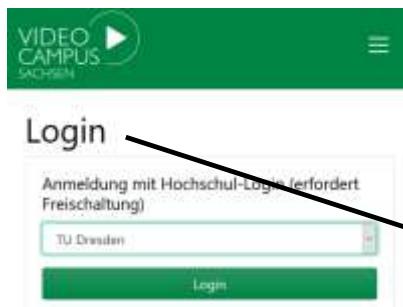


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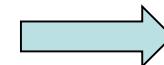
# Vacuum Technology WS 20/21

## Virtually presented Lecture 13, Feb. 02, 2021

Prof. Dr. Johann W. Bartha

Inst. f. Halbleiter und Mikrosystemtechnik  
Technische Universität Dresden

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"VT L013 a 15:24

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## 0. Introduction

Air pressure as a force to the walls of an empty container

## 1. Gas kinetic

Pressure as momentum transfer, Mol & Molvolume, Pressure units Partial pressure, Boltzmann Velocity&Energy distribution, Impingement rate, monolayer coverage time, mean free path collision rate

## 2. Pressure Ranges

Viscous, Knudsen, Molecular flow, Rough-, Medium-, High-, Ultrahigh-Vacuum, Heat conduction

## 3. Vacuum technical terms

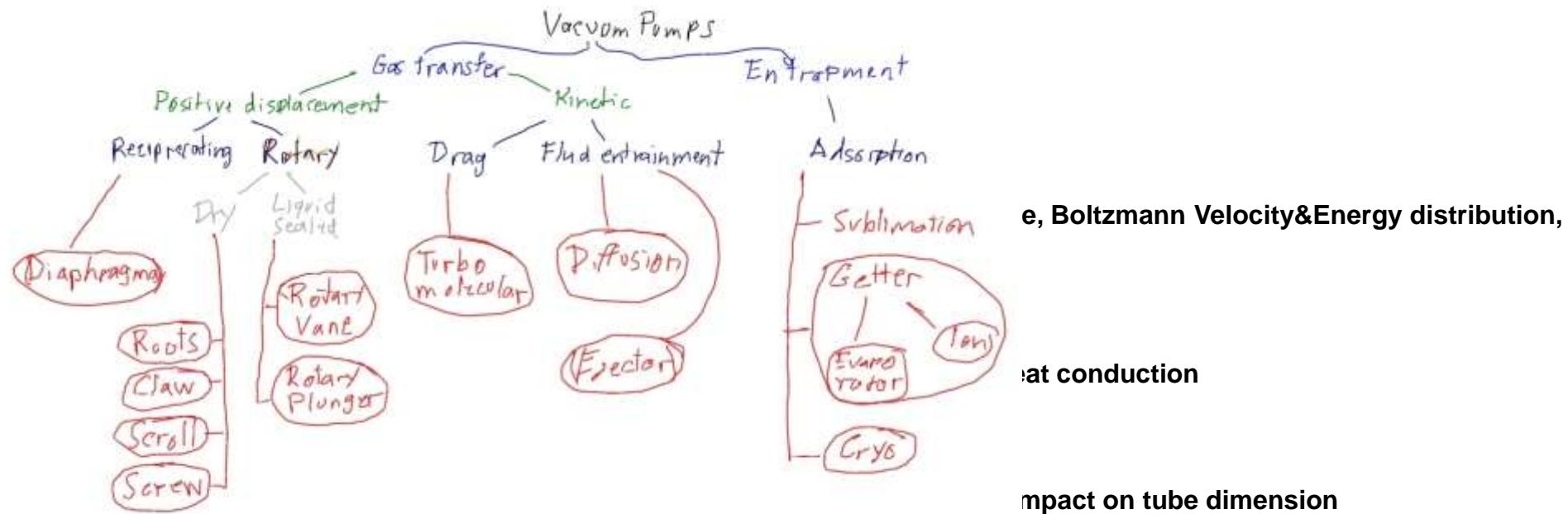
Pumping speed, pumping power, gas-flow, residence time, gas flow conduction, impact on tube dimension

## 4. Vacuum generation

Genealogy of pumps, working principle, assignment to vacuum range

## 5. Pressure measurement

Direct / Indirect pressure measurement, Different gauges and assignment to vacuum range, Partial pressure measurement, interpretation of QMA spectra

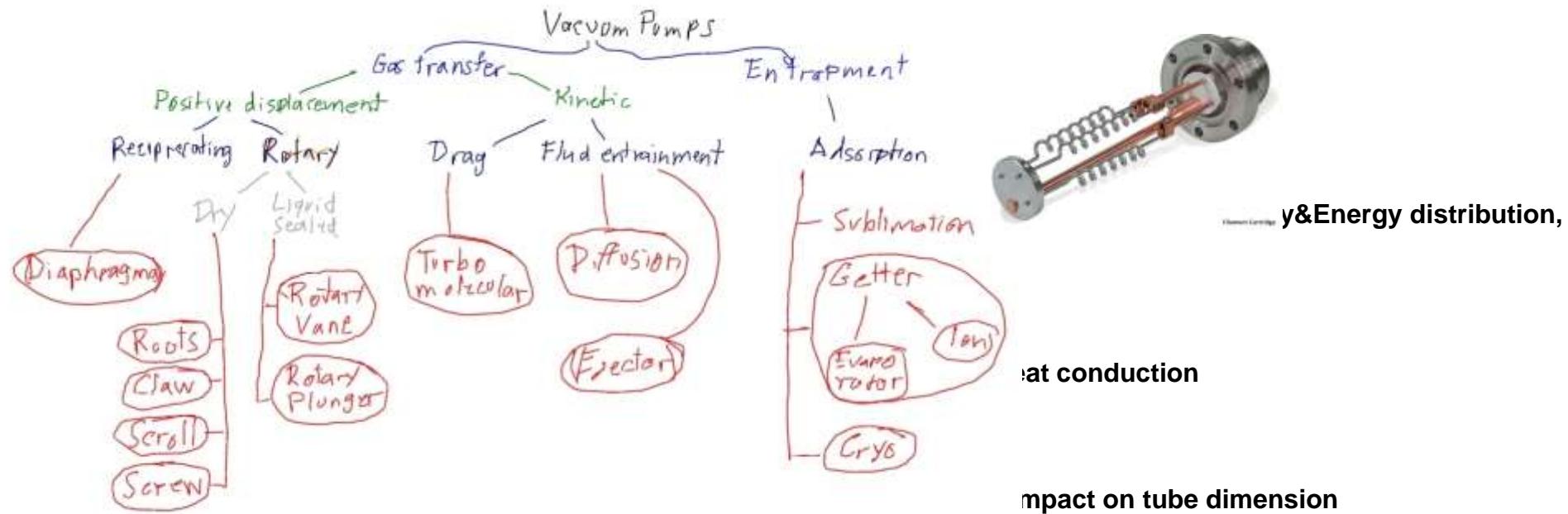


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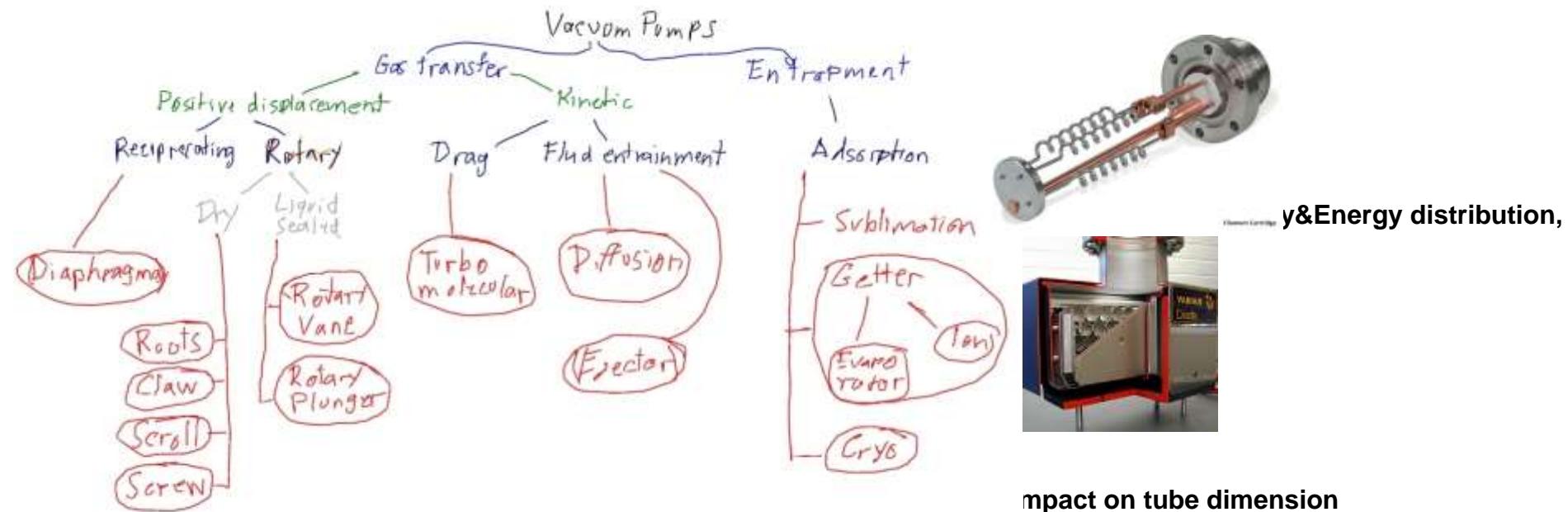


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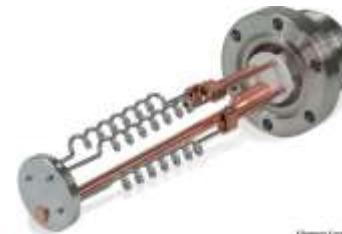
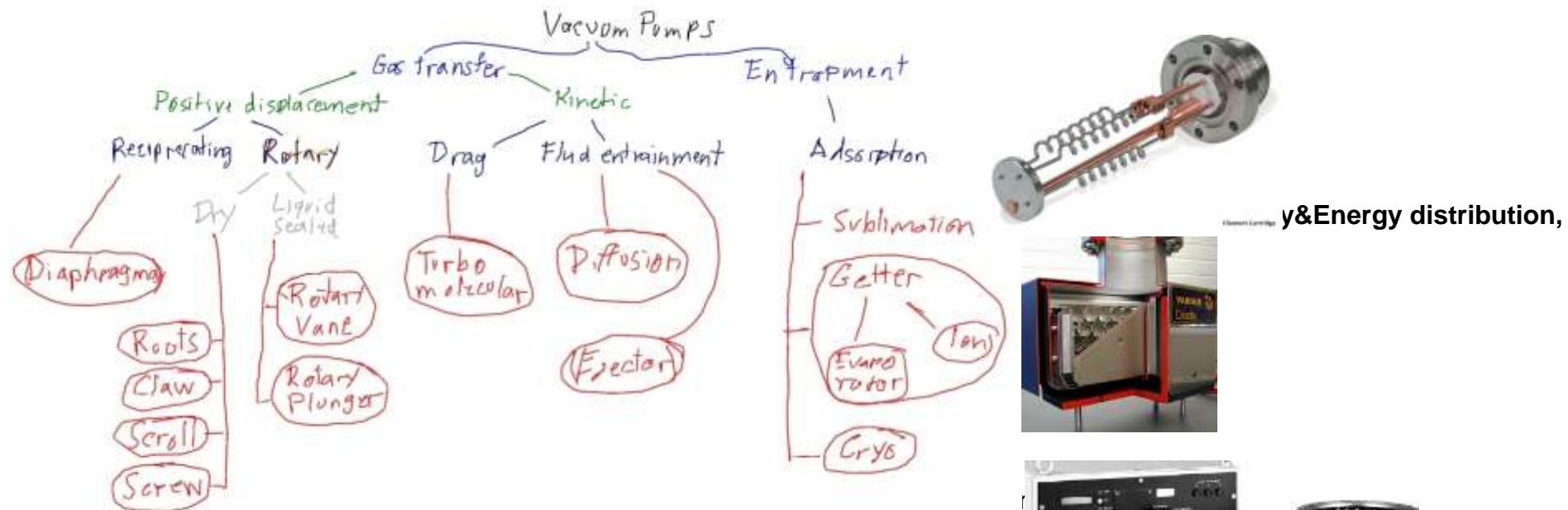


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Genealogy of pumps, working principle, assignment to vacuum range

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Direct / Indirect pressure measurement, Different gauges and assignment to vacuum range, Partial pressure measurement, interpretation of QMA spectra



y&Energy distribution,



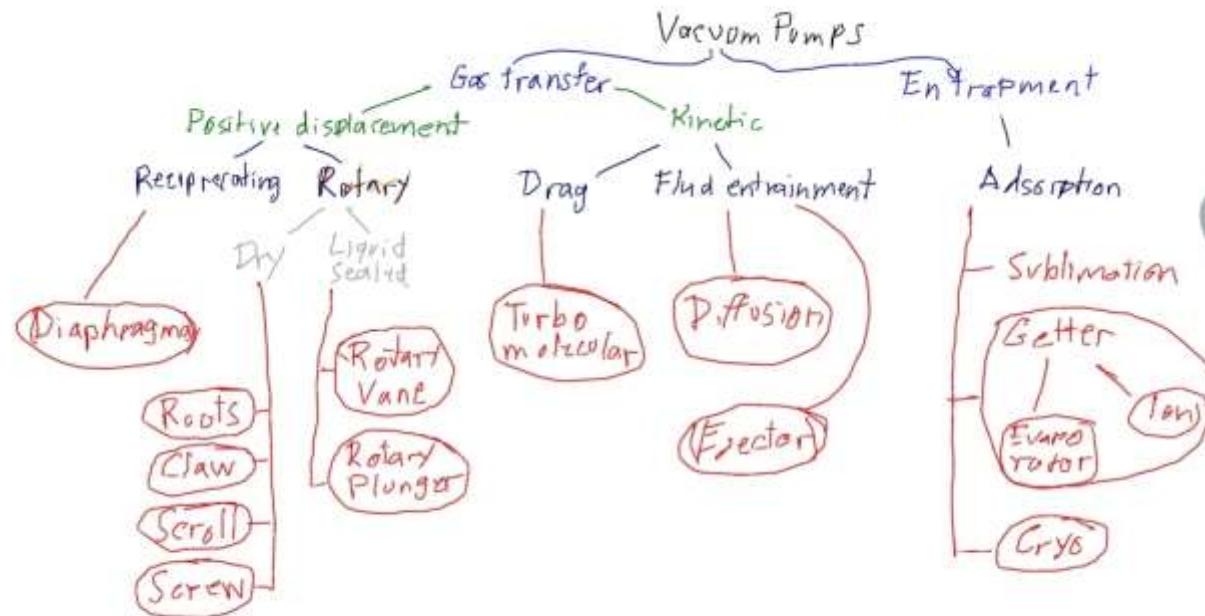
measurement,

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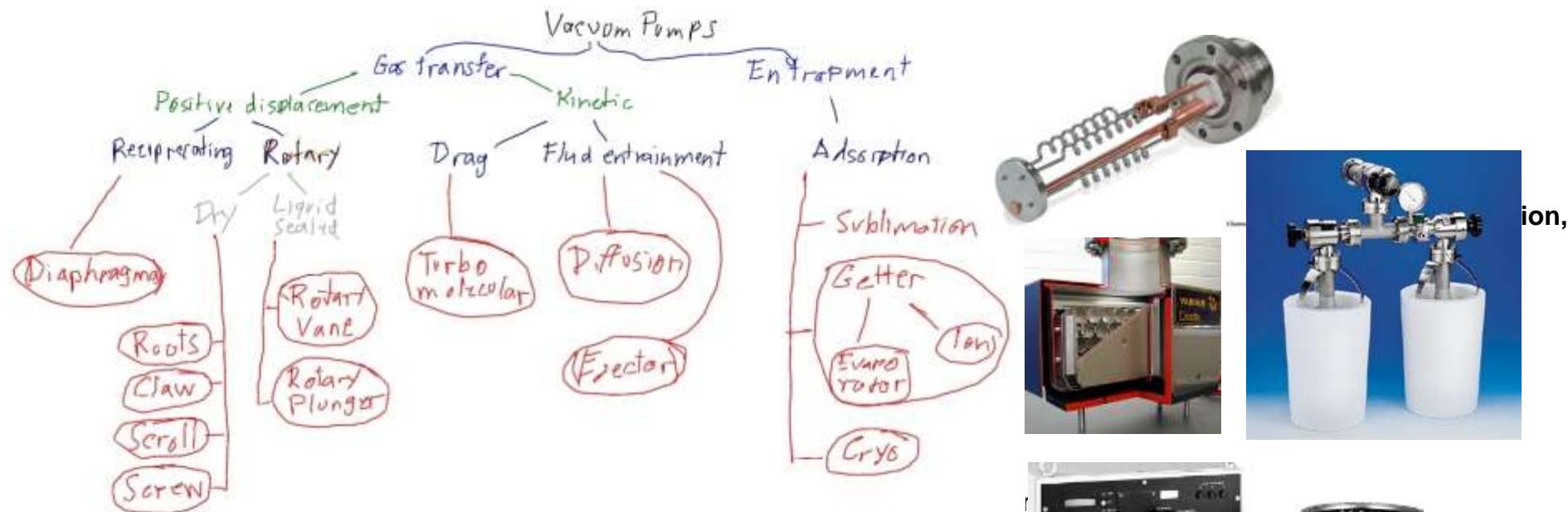


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Direct / Indirect pressure measurement, Different gauges and assignment to vac  
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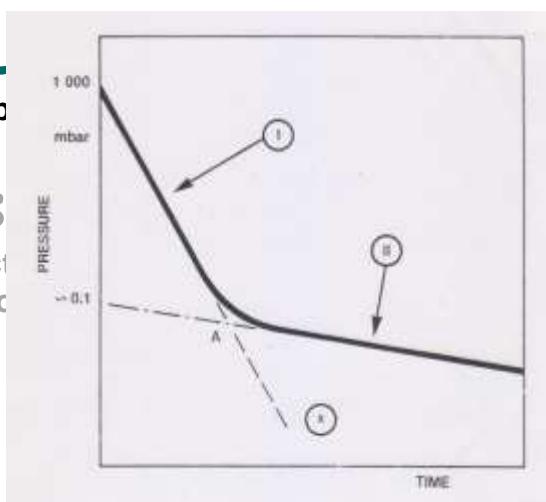


## 4. Vacuum

Genealogy of pressure

## 5. Pressure

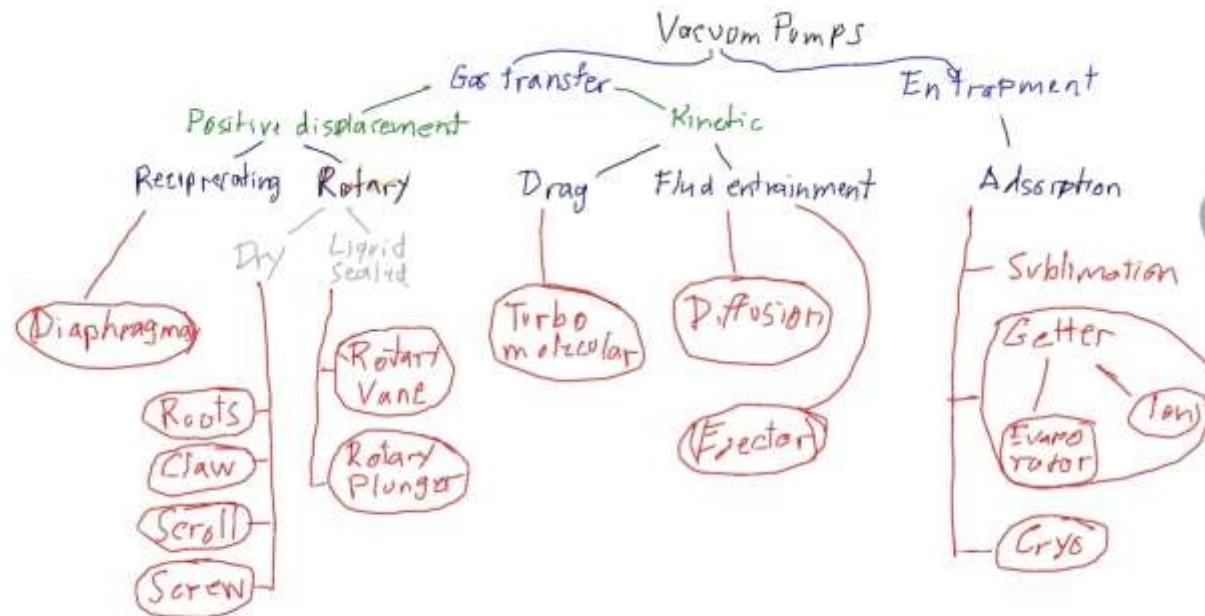
Direct / Indirect  
interpretation of pressure



nt to vacuum range

Auges and assignment to vac



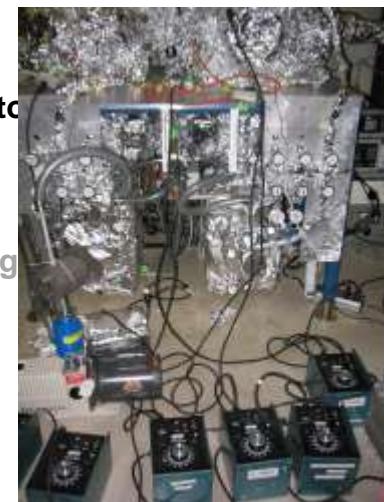
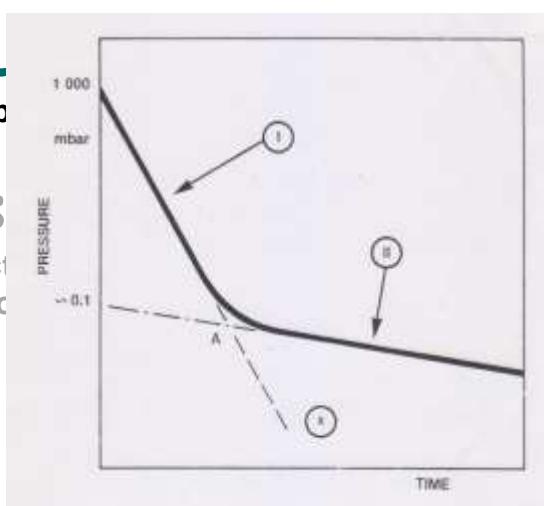


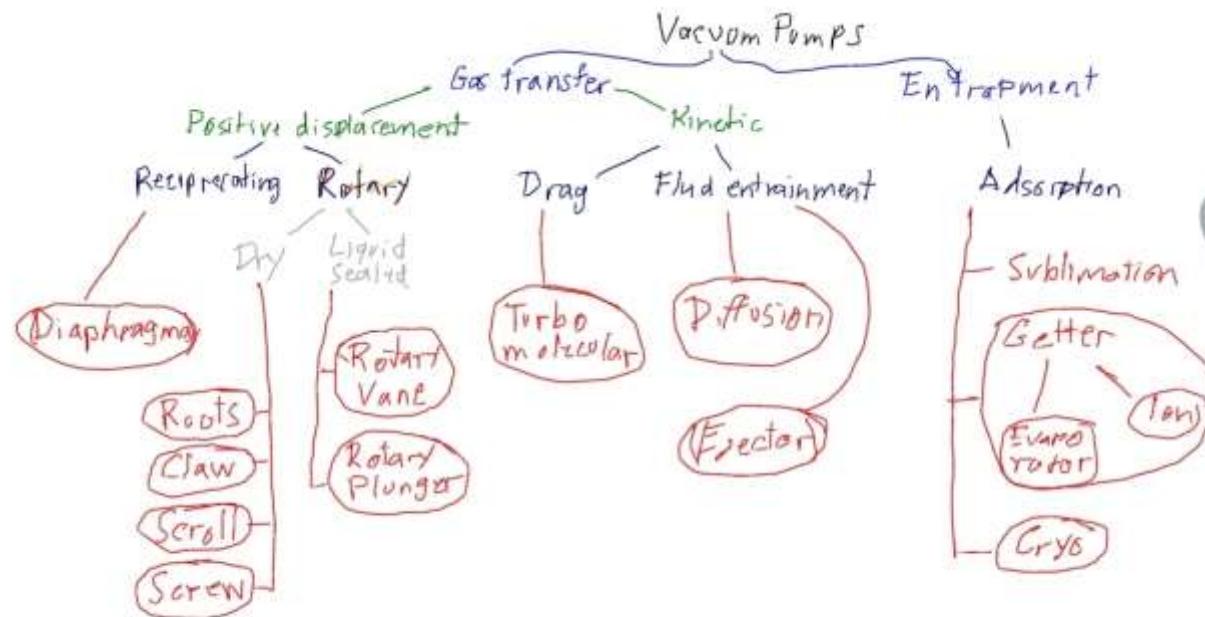
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Genealogy of pressure

## 5. Pressure

Direct / Indirect  
interpretation of pressure



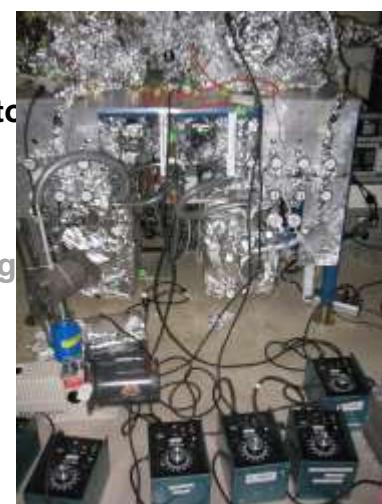
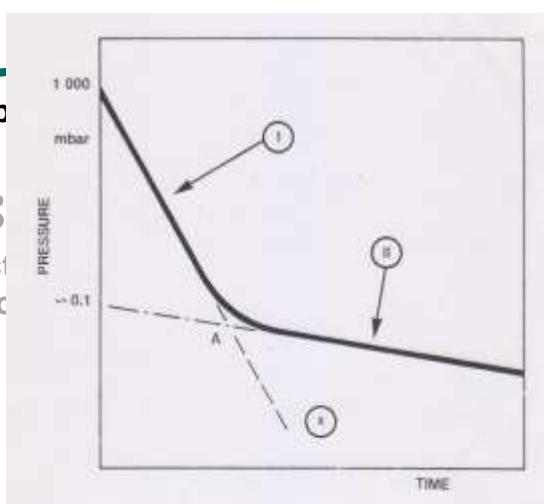


## 4. Vacuum

Genealogy of pumps

## 5. Pressure

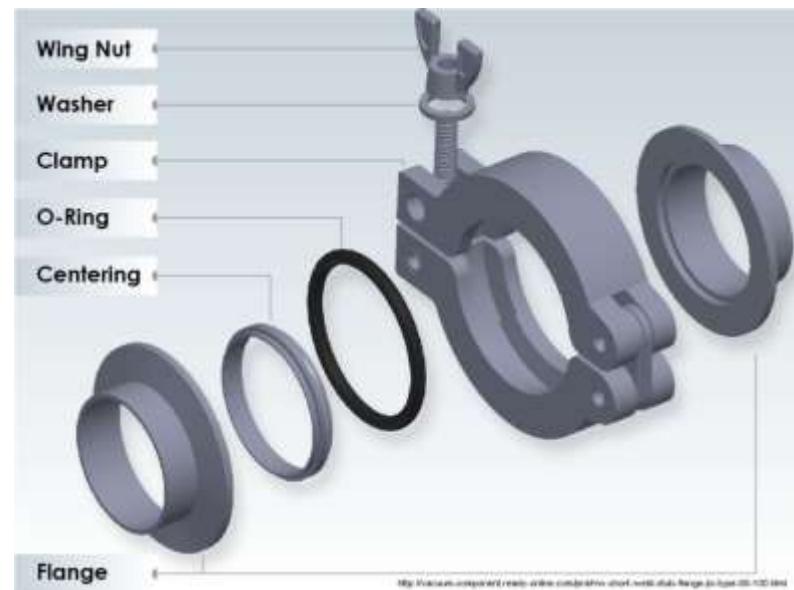
Direct / Indirect  
interpretation of pressure





Rubber based sealing

# High Vacuum flanges



# High vacuum system

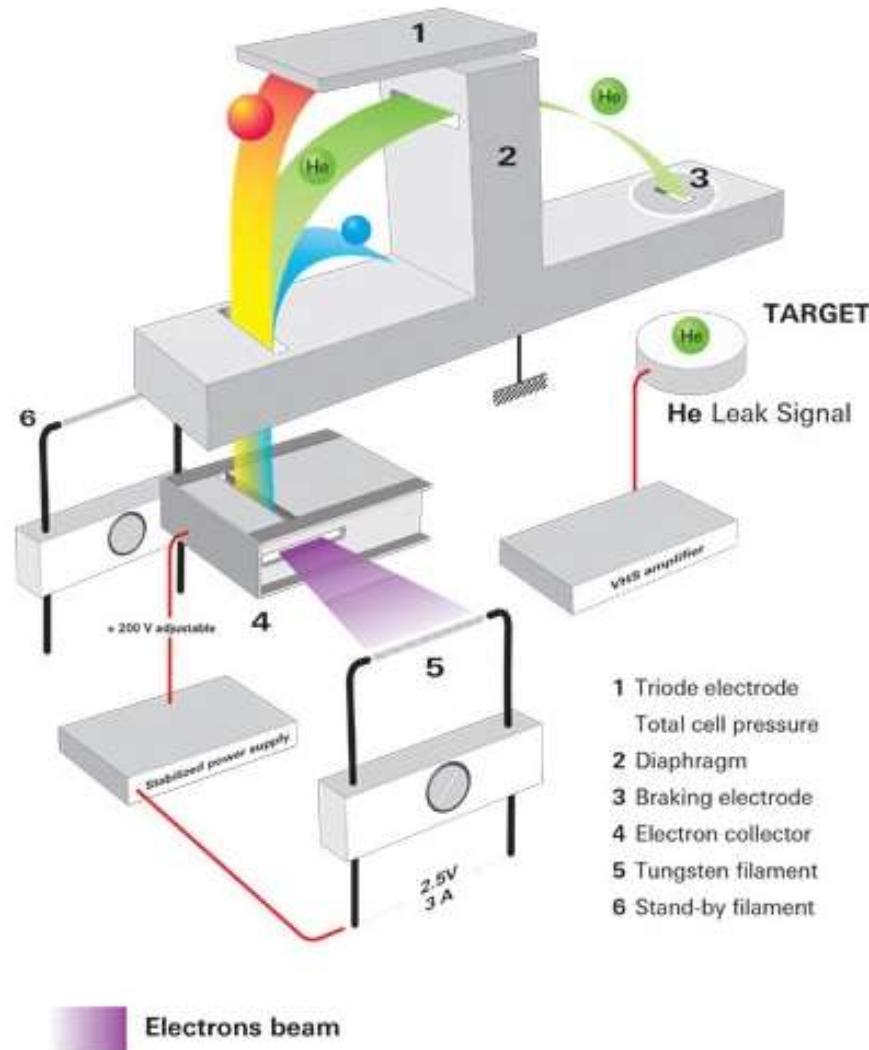


# Measurement of the He partial pressure

(regular case: He partial  
pressure not detectable!)

## Measurement of the He partial pressure

(regular case: He partial pressure not detectable!)



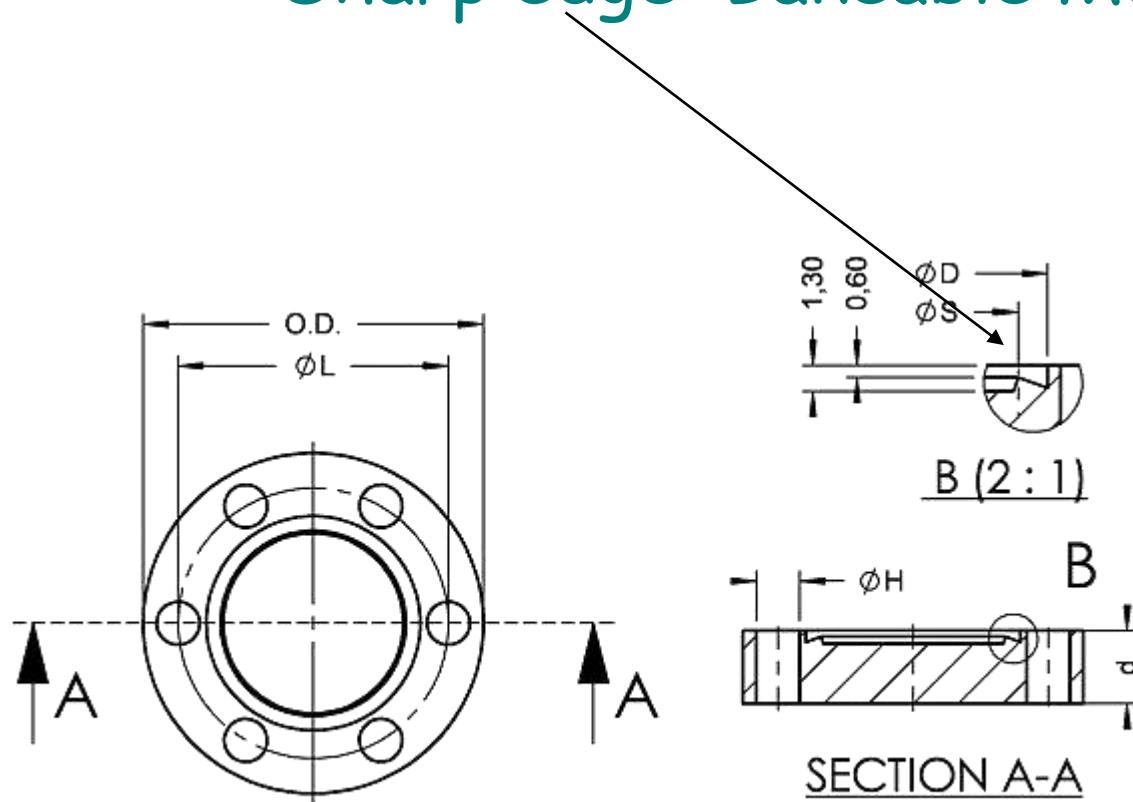
# Ultra High Vacuum



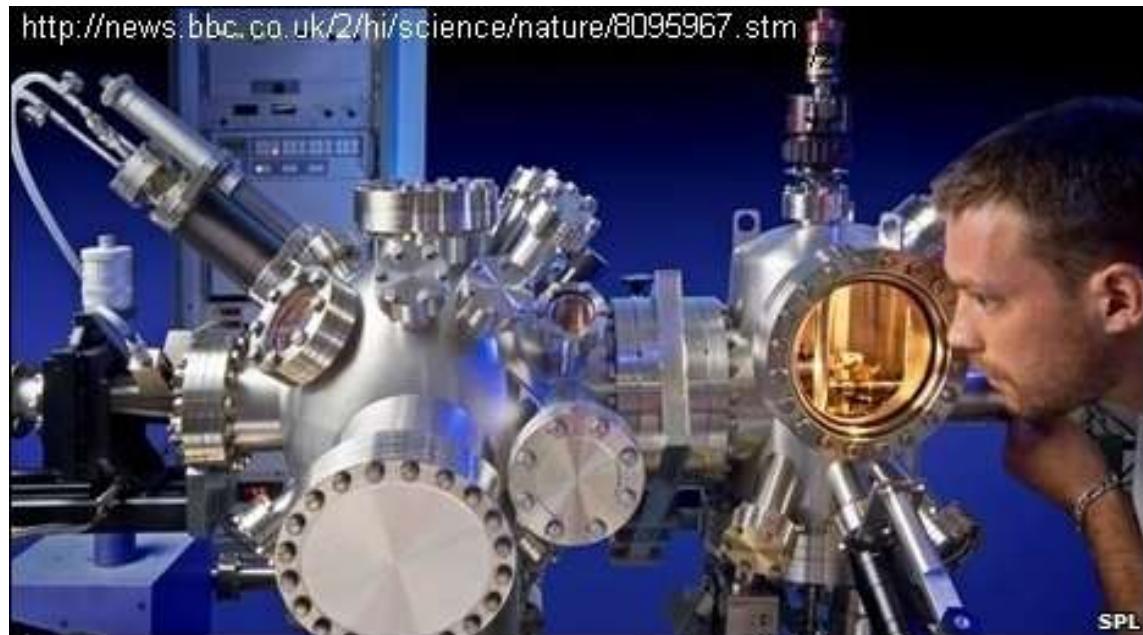
## Metal based sealing



## Sharp edge: Bakeable Metall-Metall join



# Ultra High Vacuum systems







# 5. Vacuum measurement

## 5.1. Pressure measurement

# 5. Vacuum measurement

## 5.1. Pressure measurement

A: Direct or absolute pressure measurement  
= Force / Surface area

!! Independent of the specific gas



# 5. Vacuum measurement

## 5.1. Pressure measurement

A: Direct or absolute pressure measurement  
= Force / Surface area

!! Independent of the specific gas

B: Indirect pressure measurement  
= Utilization of density dependent properties

- Heat conductivity
- Ionization probability

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- Ionization probability

Mechanical:  
Bending device

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- Ionization probability

Mechanical:  
Bending device

Electrical:  
Baratron

# 5. Vacuum measurement

## 5.1. Pressure measurement

A: Direct or absolute pressure measurement  
= Force / Surface area

!! Independent of the specific gas

Mechanical:  
Bending device

Electrical:  
Baratron

B: Indirect pressure measurement  
= Utilization of density dependent properties

- Heat conductivity
- Ionization probability

- Pirani
- Penning
- Hot cathode

# 5. Vacuum measurement

5.2 Gas flow

## 5.1. Pressure measurement

A: Direct or absolute pressure measurement  
= Force / Surface area

!! Independent of the specific gas

Mechanical:  
Bending device

Electrical:  
Baratron

B: Indirect pressure measurement  
= Utilization of density dependent properties

- Heat conductivity
- Ionization probability

- Pirani
- Penning
- Hot cathode

# 5. Vacuum measurement

5.2 Gas flow

## 5.1. Pressure measurement

5.3 Partial pressure

A: Direct or absolute  
pressure measurement  
= Force / Surface area

!! Independent of the  
specific gas

Mechanical:  
Bending device

Electrical:  
Baratron

B: Indirect pressure  
measurement  
= Utilization of density  
dependent properties

-Heat conductivity  
-Ionization probability

- Pirani
- Penning
- Hot cathode

# A: Bourdon Vacuum meter

Covers the rough vacuum range



# A: Bourdon Vacuum meter

Covers the rough vacuum range



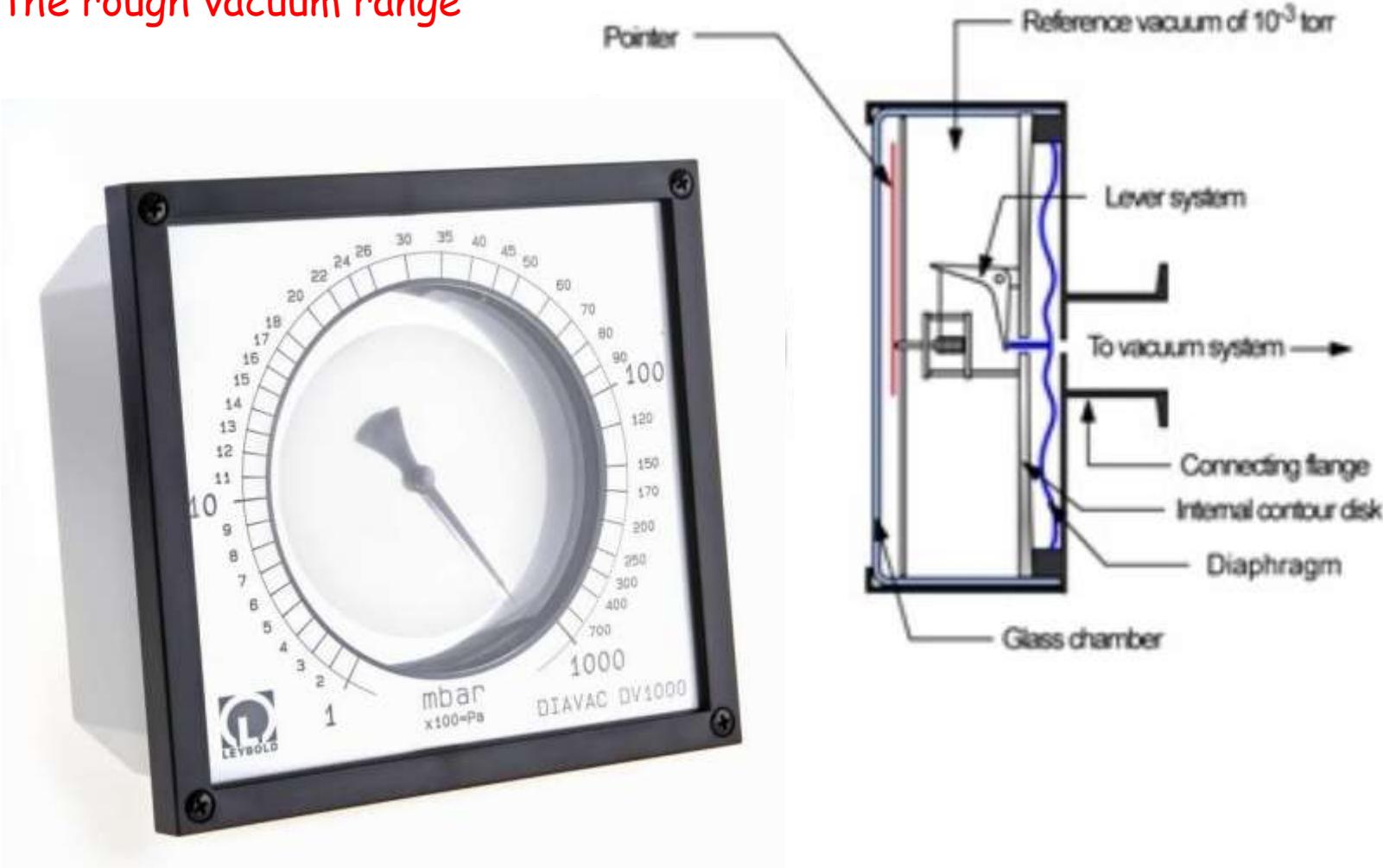
# A: Bourdon Vacuum meter

Covers the rough vacuum range



# A: Membrane Vacuum meter

Covers the rough vacuum range



## A: Baratron

Covers wide  
vacuum range  
 $1000 - 10^{-5}$  mBar

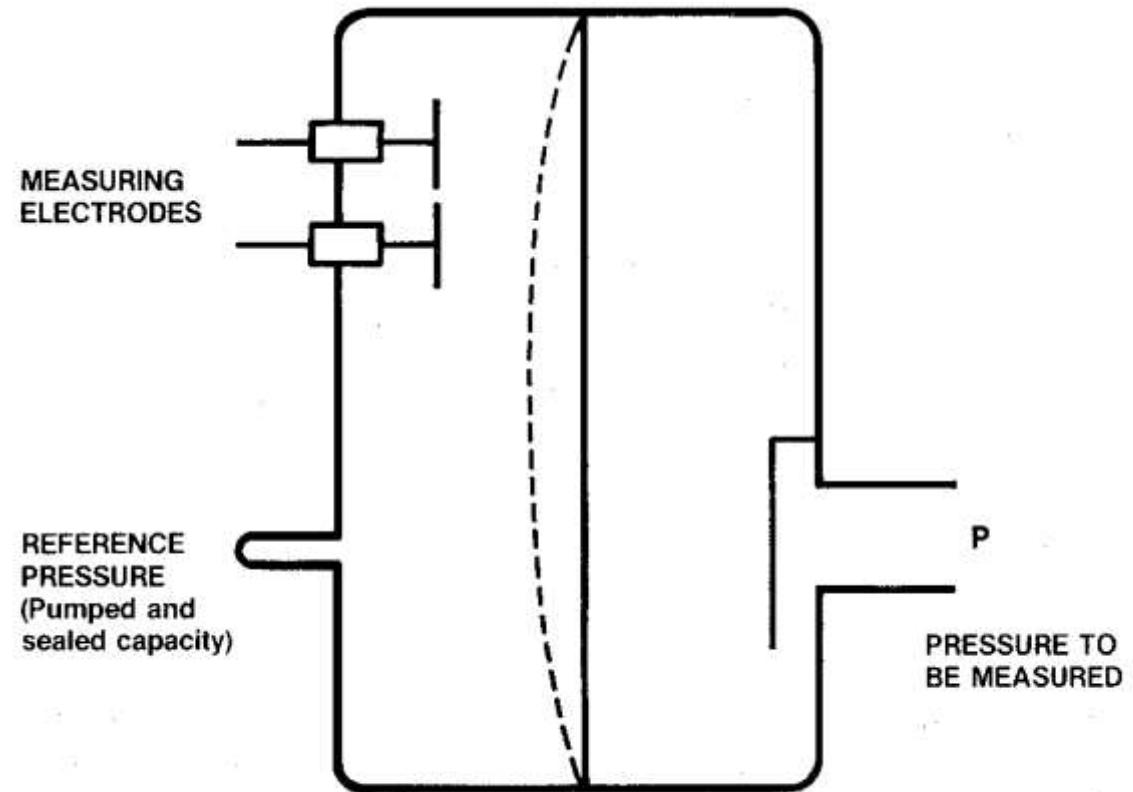


Fig. 9.5. Capacitance manometer with deformable membrane (schematic).

## A: Baratron

Covers wide  
vacuum range  
 $1000 - 10^{-5}$  mBar

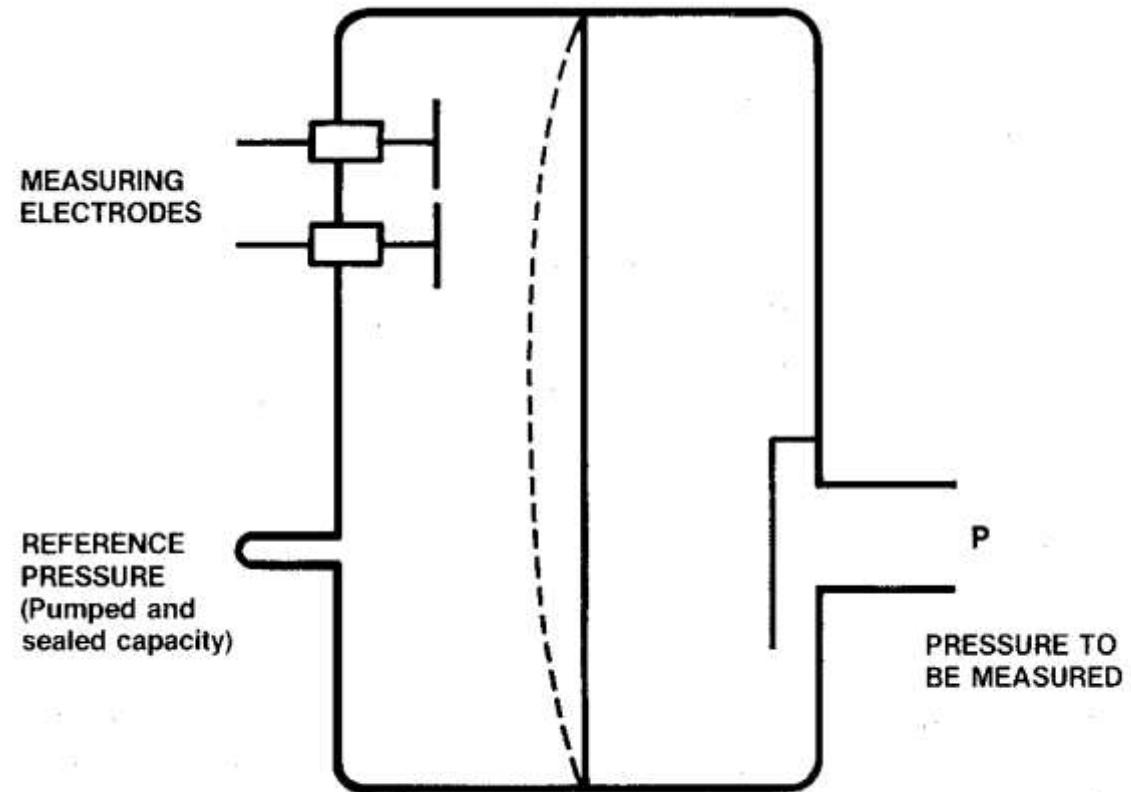
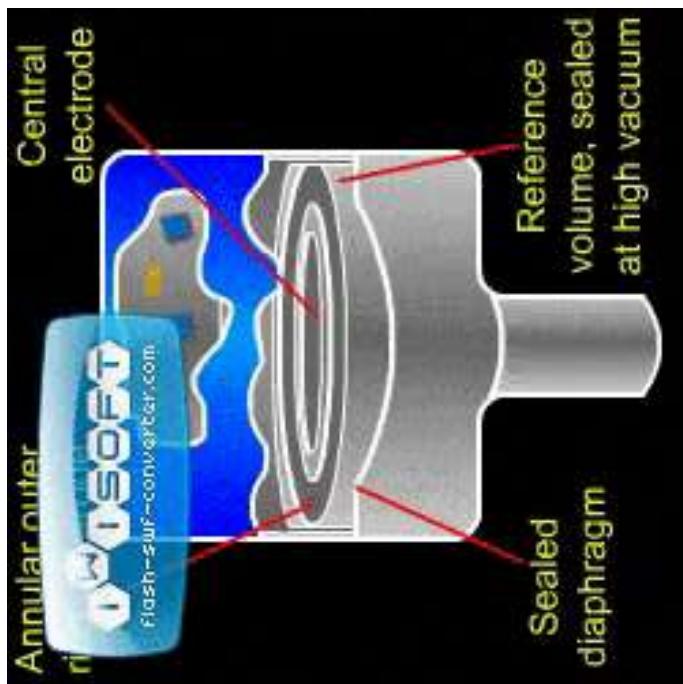
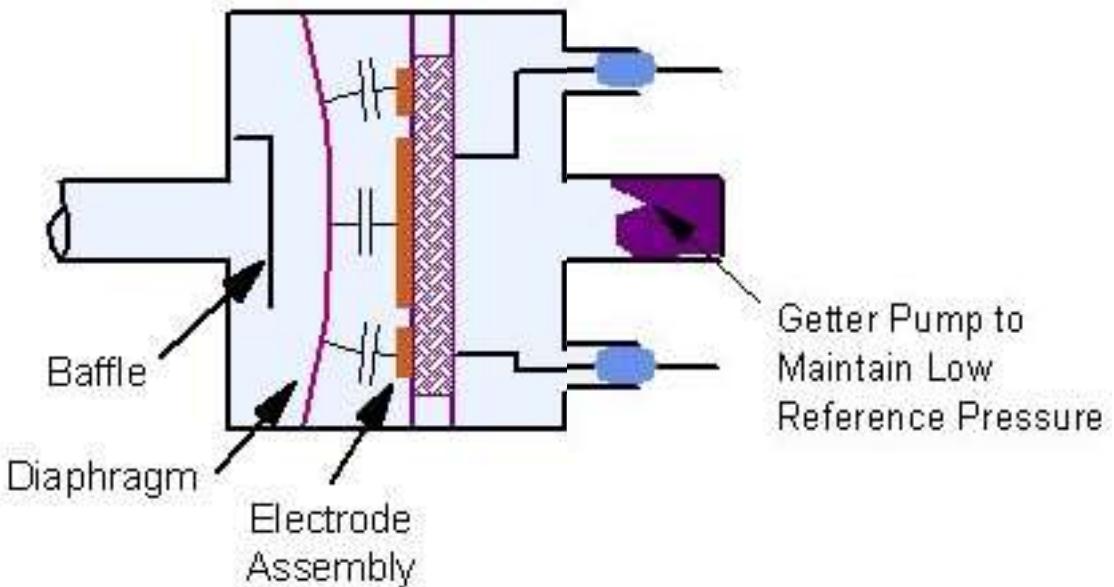


Fig. 9.5. Capacitance manometer with deformable membrane (schematic).

# A: Baratron



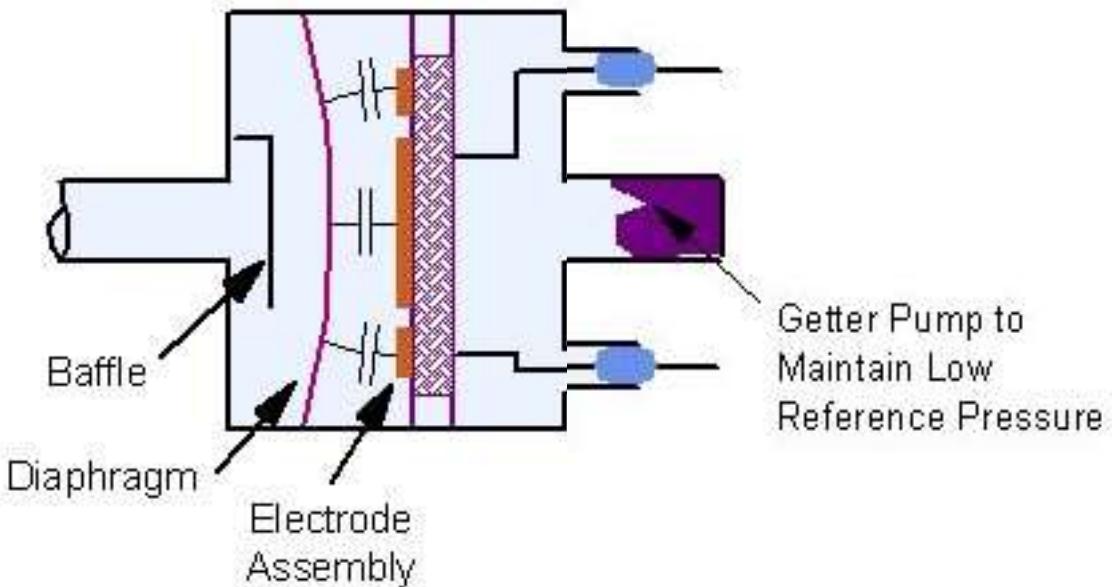
## Sensor (Full Scale)

- 1000
- 100
- 10
- 1
- 0,1

## Messbereich in mbar

- |                    |                    |
|--------------------|--------------------|
| ■ 1013             | - 10 <sup>-1</sup> |
| ■ 100              | - 10 <sup>-2</sup> |
| ■ 10               | - 10 <sup>-3</sup> |
| ■ 1                | - 10 <sup>-4</sup> |
| ■ 10 <sup>-1</sup> | - 10 <sup>-5</sup> |

## A: Baratron



### Sensor (Full Scale)

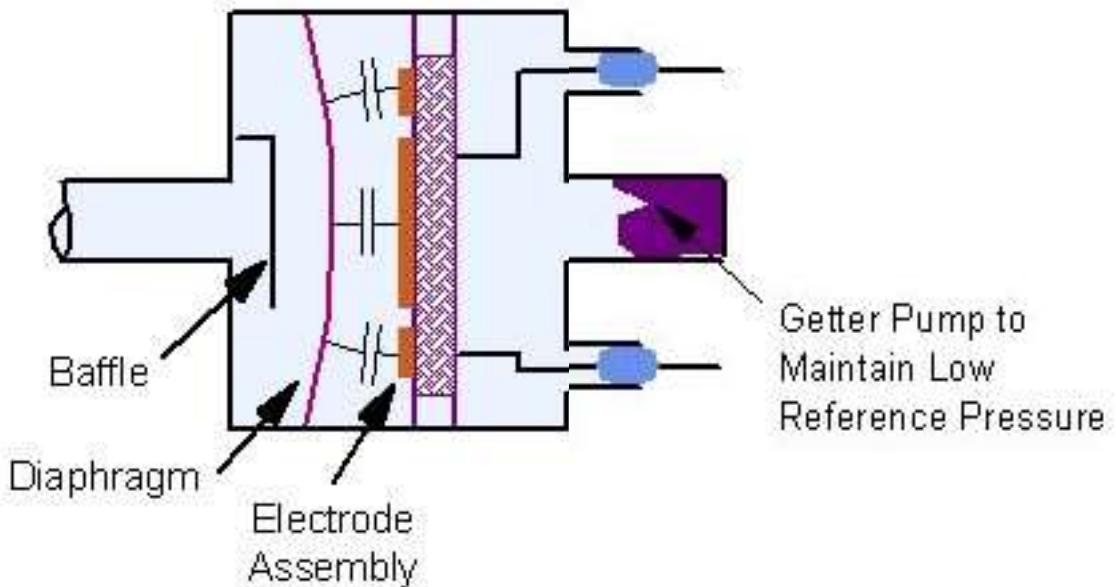
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| ■ 1                | - 10 <sup>-4</sup> |
| ■ 10 <sup>-1</sup> | - 10 <sup>-5</sup> |

Rough-, Fine- and part  
of High Vacuum

# A: Baratron



## Sensor (Full Scale)

- 1000
- 100
- 10
- 1
- 0,1

## Messbereich in mbar

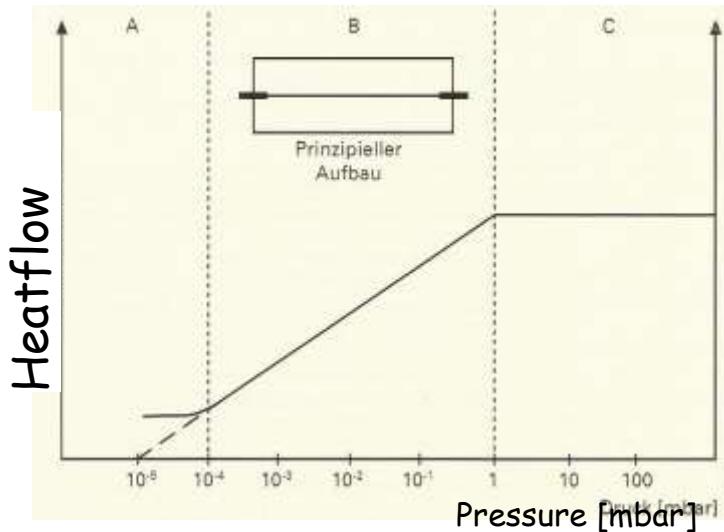
- |                    |                    |
|--------------------|--------------------|
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| ■ 1                | - 10 <sup>-4</sup> |
| ■ 10 <sup>-1</sup> | - 10 <sup>-5</sup> |

Rough-, Fine- and part  
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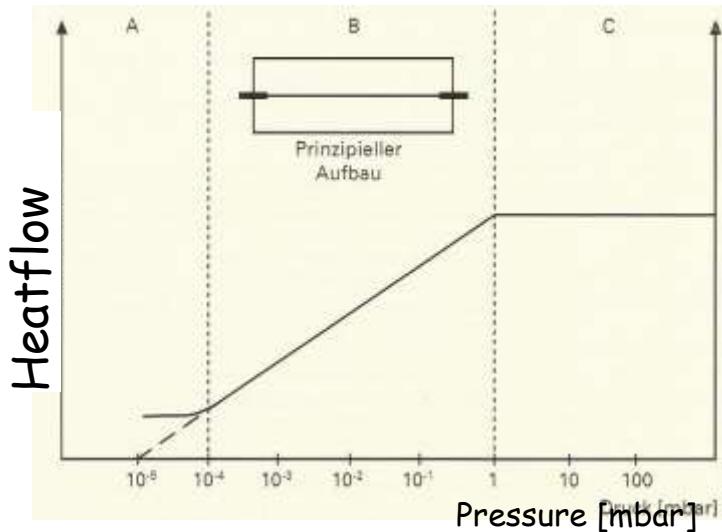
## B: Heat conduction gauge - Pirani

"VTL013 ^d 32:25



## B: Heat conduction gauge - Pirani

"VTL013 ^d 32:25



Heat flow from a heated wire inside the vacuum in regimes A,B,C by:

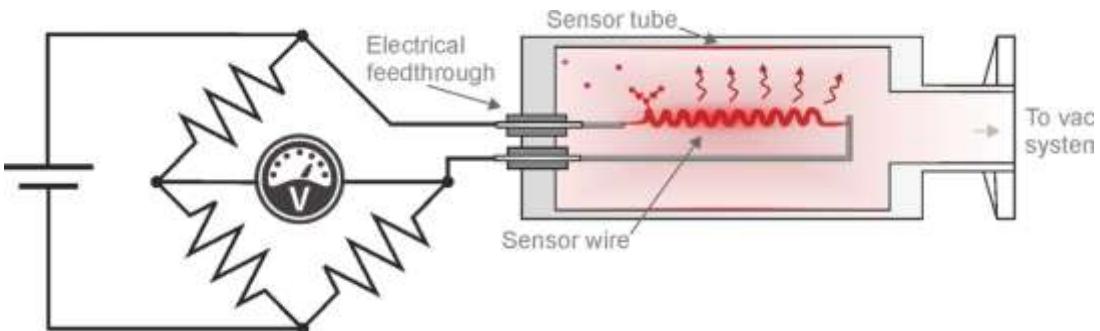
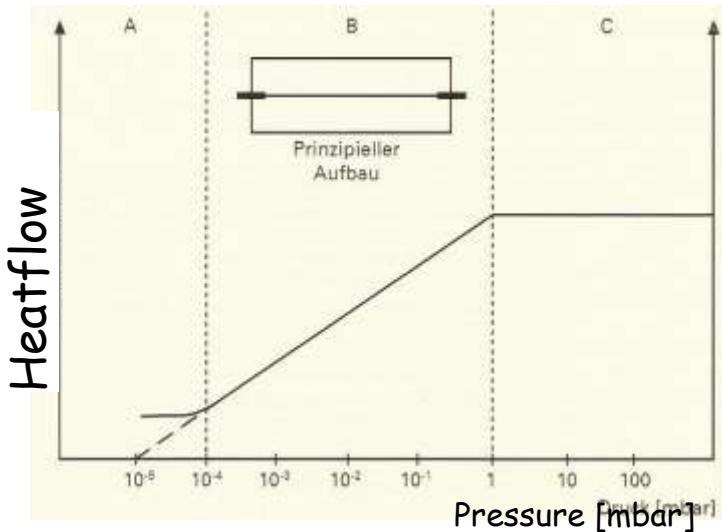
A: Radiation and conduction through terminals

B: As A + pressure dependent gas conduction

C: As A + pressure independent gas conduction

# B: Heat conduction gauge - Pirani

"VT L013 ^d 32:25



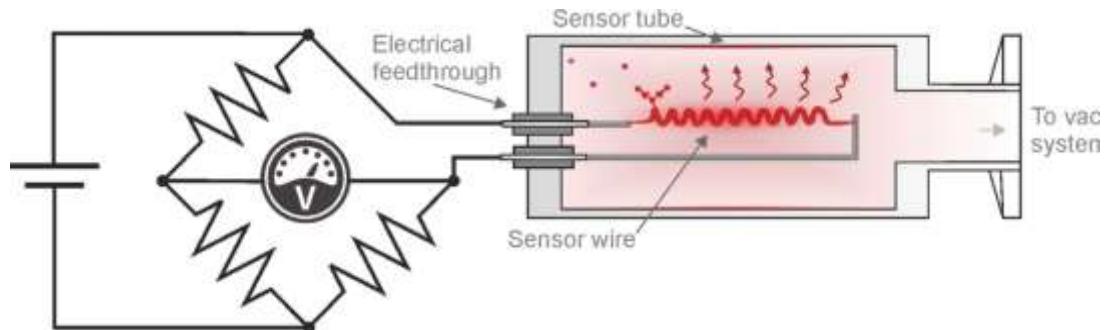
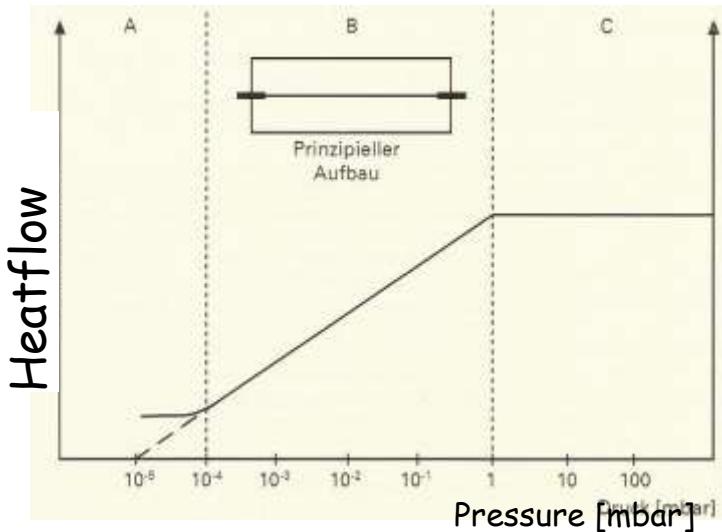
Metal wire heated by current →  
Change of pressure changes heat flow which  
changes the resistivity and unbalances the  
Wheatstone bridge.

Heat flow from a heated wire inside the vacuum in regimes A,B,C by:

- A: Radiation and conduction through terminals
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"VT L013 ^d 32:25

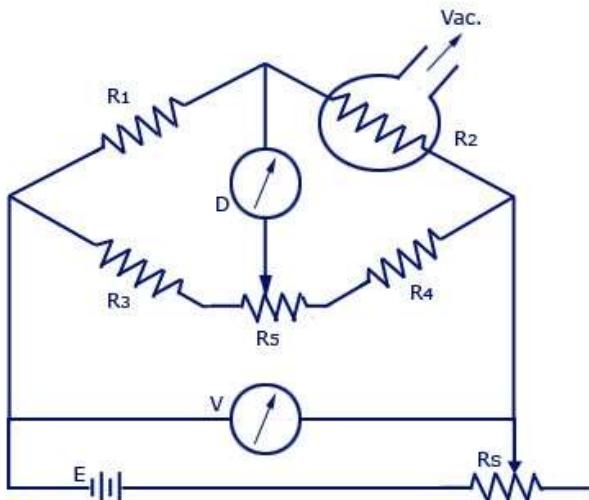


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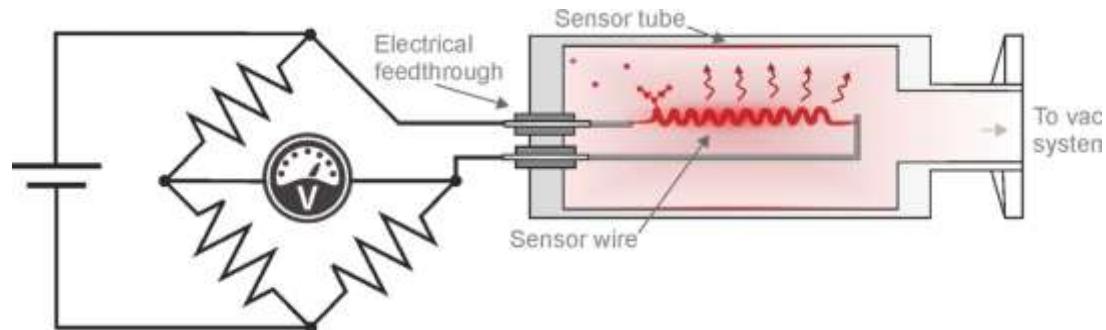
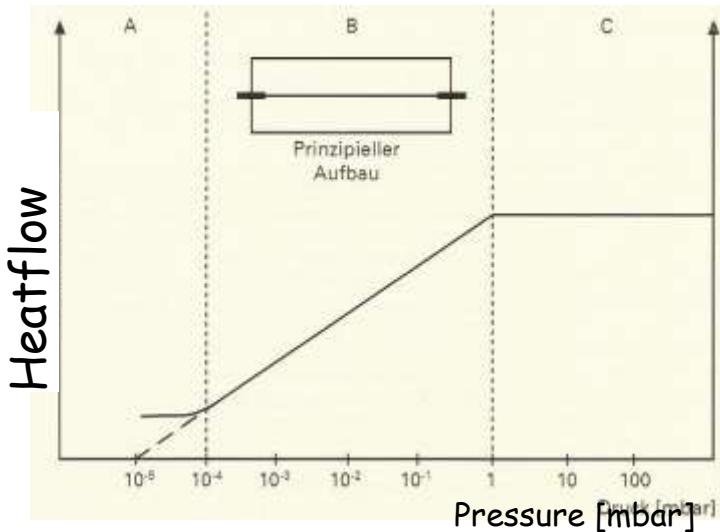
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Pirani Gauge



## B: Heat conduction gauge - Pirani

"VT L013 ^d 32:25

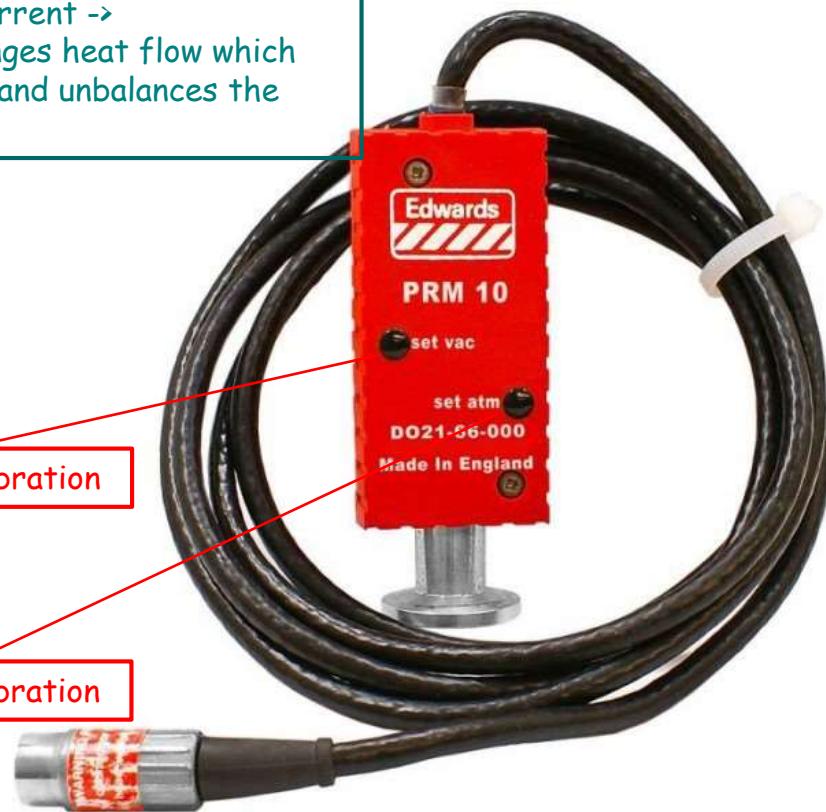
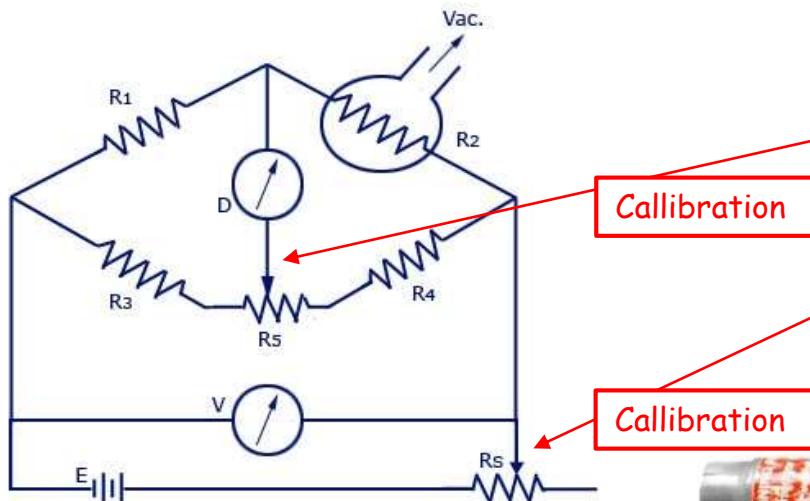


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Pirani Gauge



## B: Heat Conduction gauge - Pirani



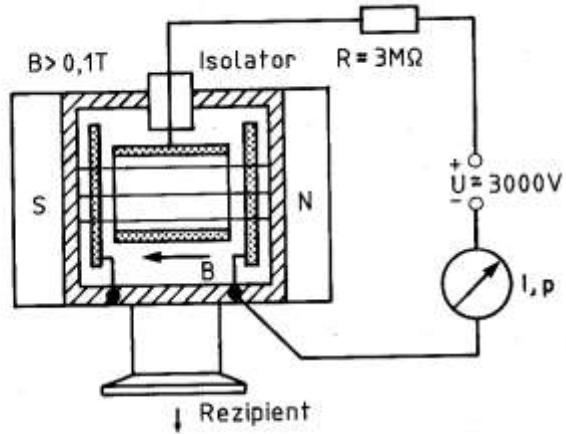
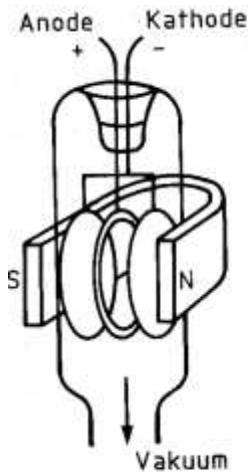
## B: Heat Conduction gauge - Pirani

Sensitive in medium vacuum range



## B: Cold cathode manometer - Penning

Covers the high vacuum range

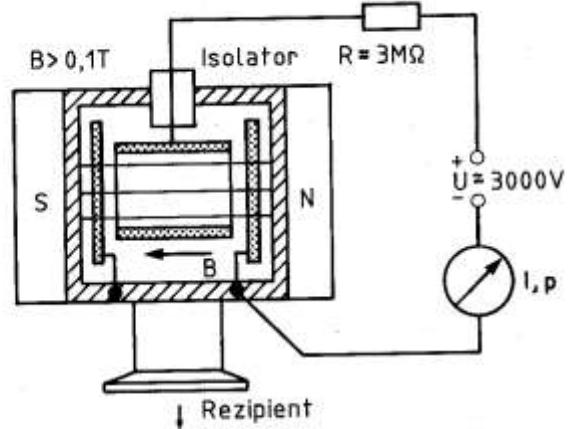
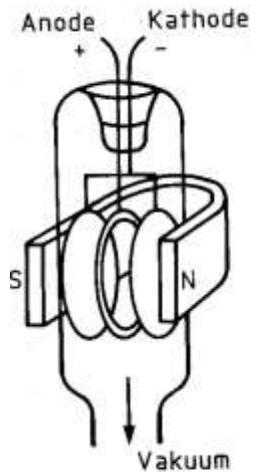


Ionisationsvakuummeter mit kalter Kathode nach Penning

- a) Glasausführung mit Anodenring
- b) Ganzmetallausführung mit Anodenzyylinder

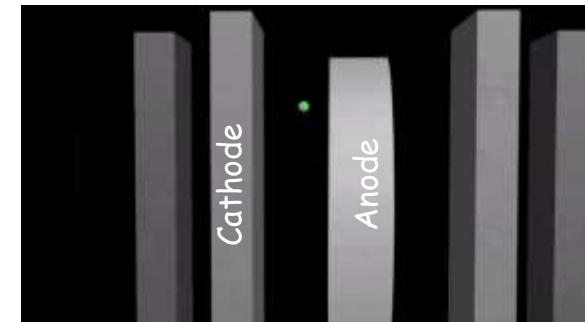
## B: Cold cathode manometer - Penning

Covers the high vacuum range



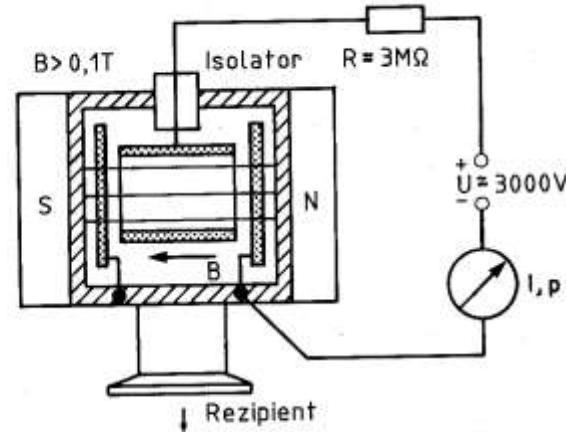
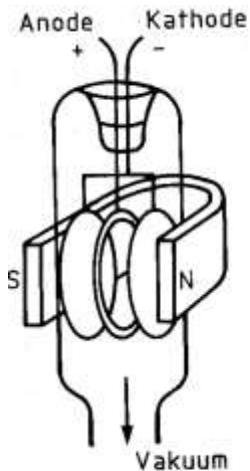
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## B: Cold cathode manometer - Penning

Covers the high vacuum range



Ionisationsvakuummeter mit kalter Kathode nach Penning

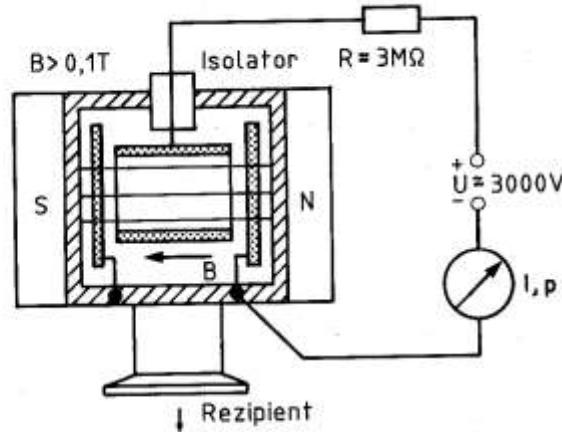
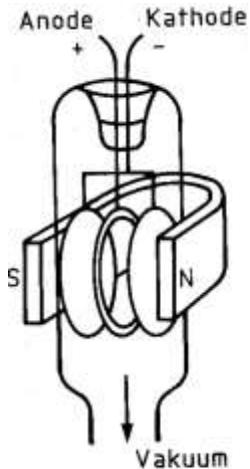
- a) Glasausführung mit Anodenring
- b) Ganzmetallausführung mit Anodenzyylinder

Probability for  
electron impact  
ionization in HV  
becomes very low  
=> confinement of  
electrons in a magnetic  
field! Large MFP!



## B: Cold cathode manometer - Penning

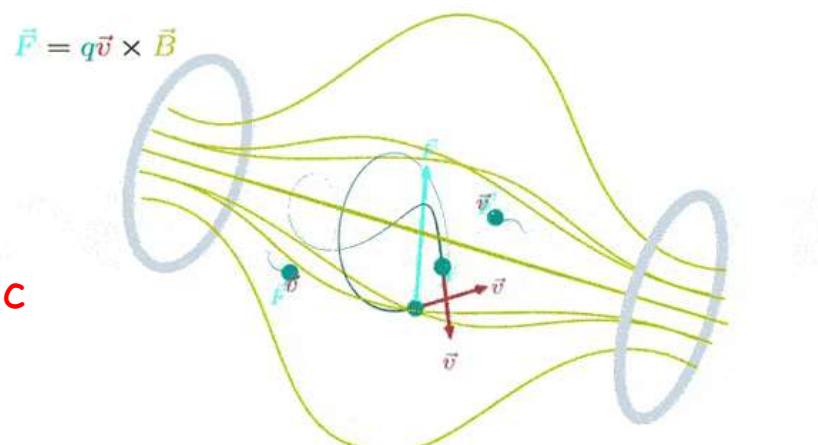
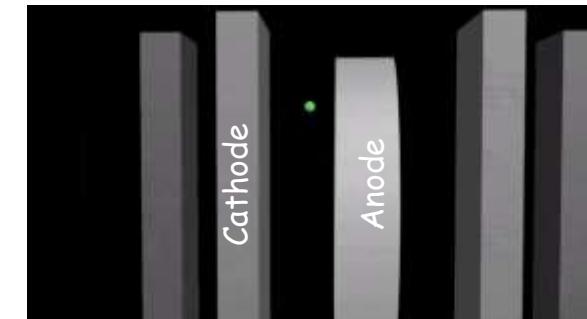
Covers the high vacuum range



Ionisationsvakuummeter mit kalter Kathode nach Penning

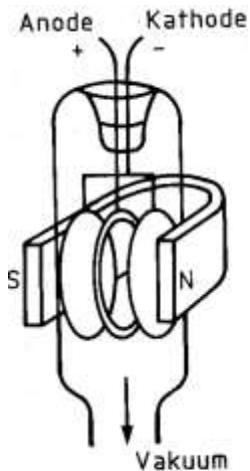
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# B: Cold cathode manometer - Penning

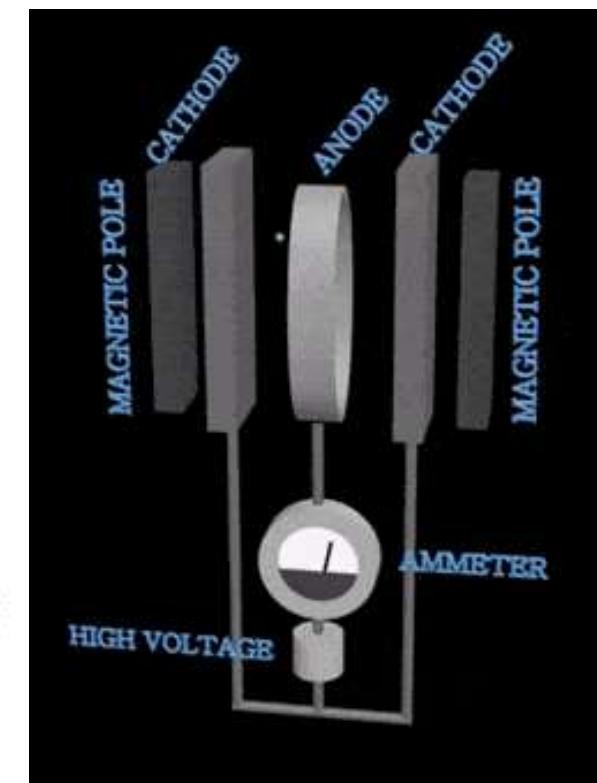
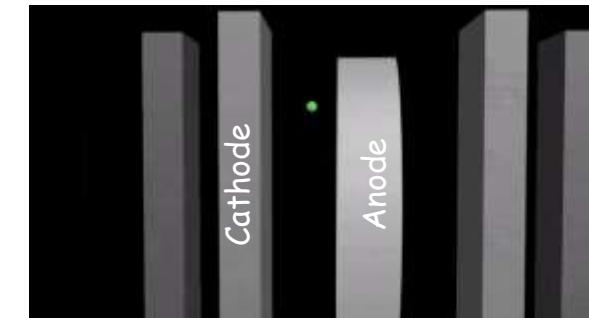
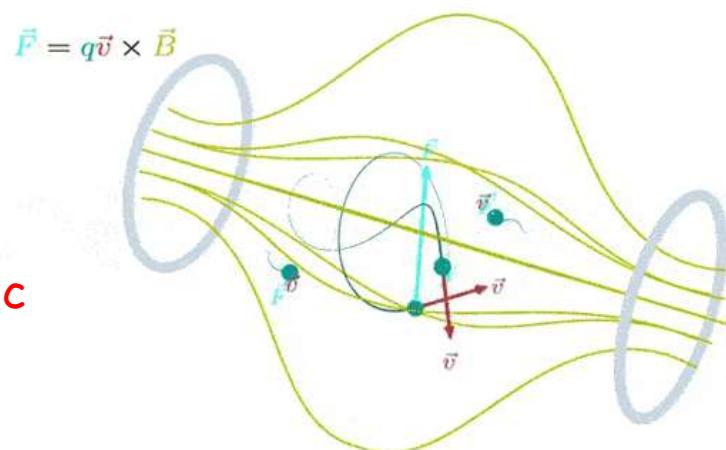
Covers the high vacuum range



Ionisationsvakuummeter mit kalter Kathode nach Penning

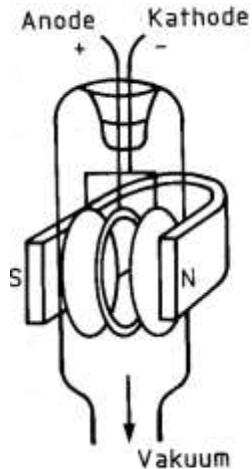
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## B: Cold cathode manometer - Penning

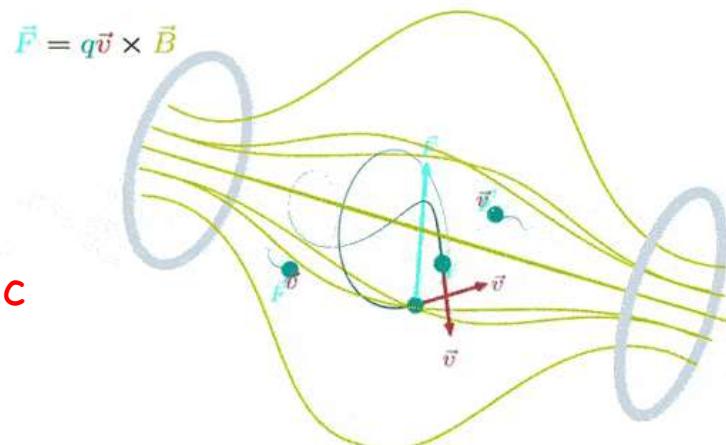
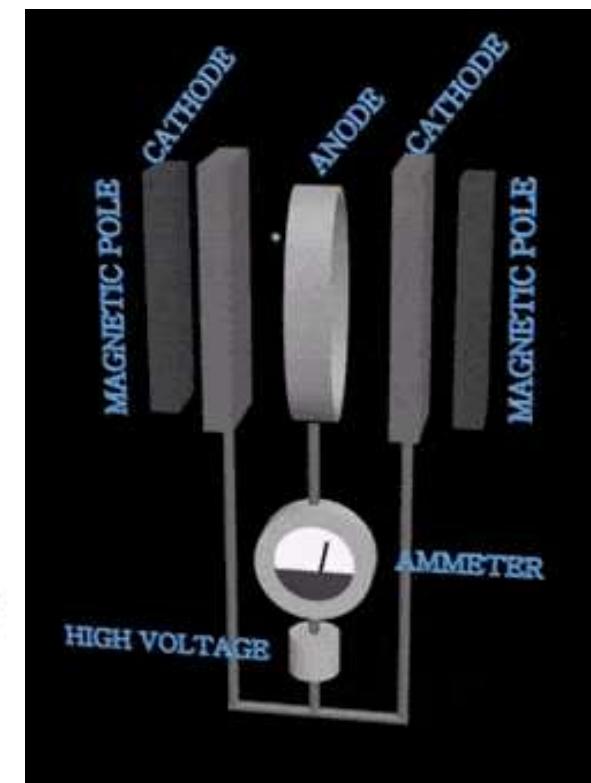
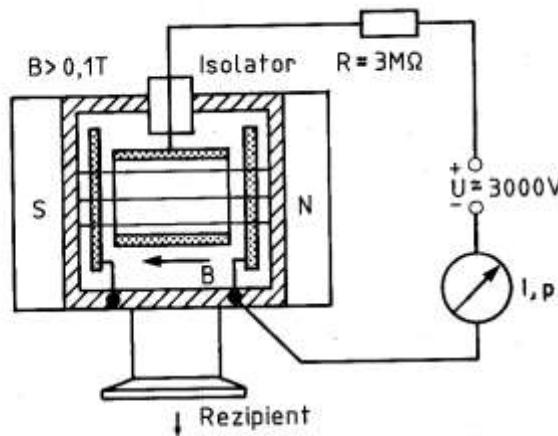
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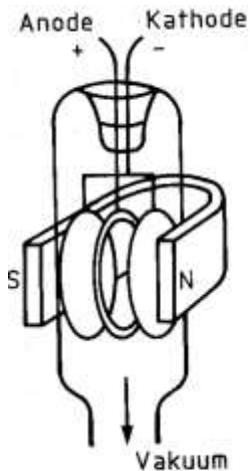
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# B: Cold cathode manometer - Penning

## Appears familiar?

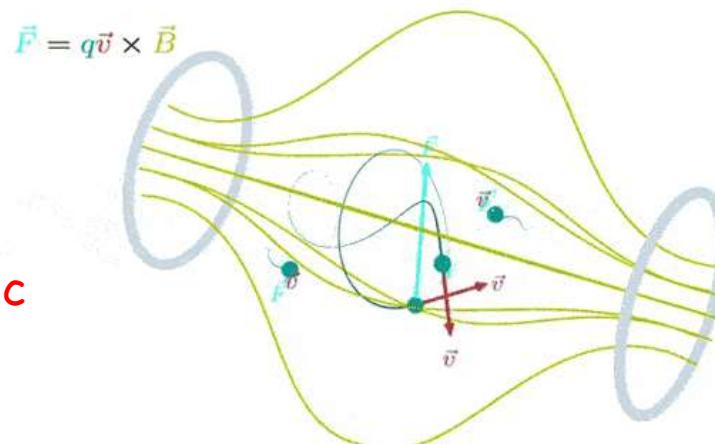
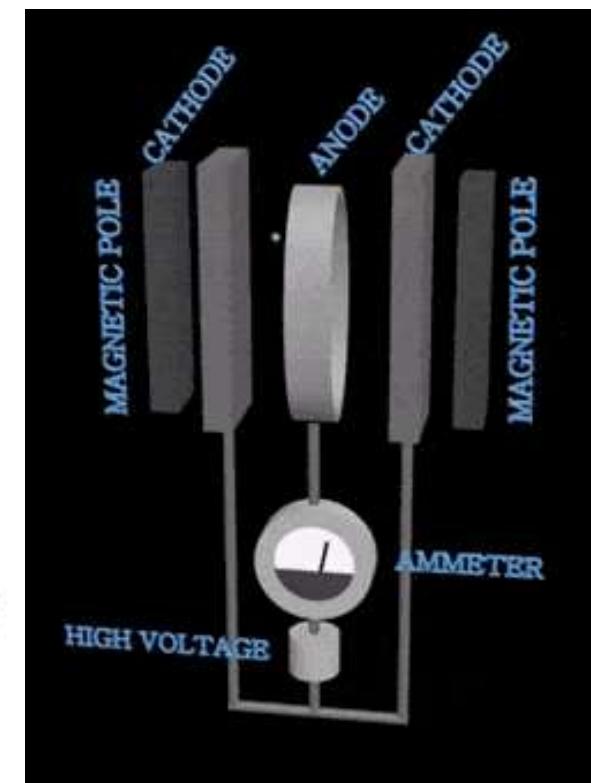
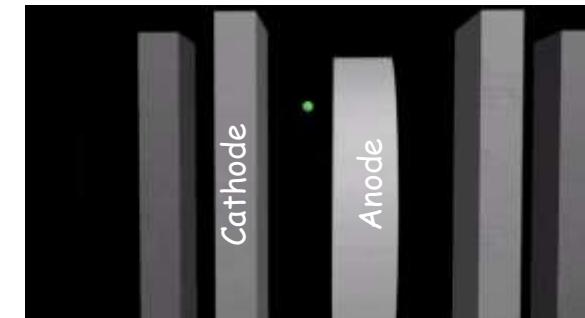
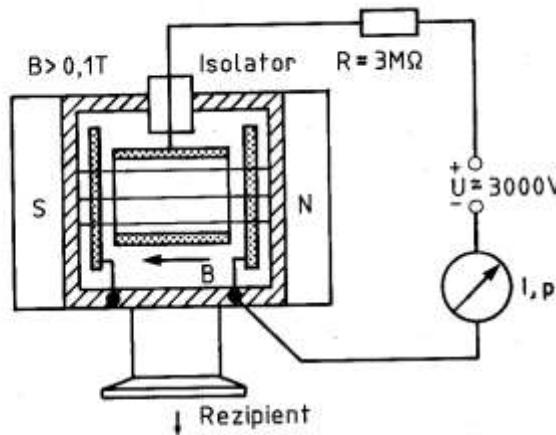
Covers the high vacuum range



Ionisationsvakuummeter mit kalter Kathode nach Penning

- a) Glasausführung mit Anodenring
- b) Ganzmetallausführung mit Anodenzyliner

Probability for electron impact ionization in HV becomes very low  
=> confinement of electrons in a magnetic field! Large MFP!



## B: Cold cathode manometer - Penning



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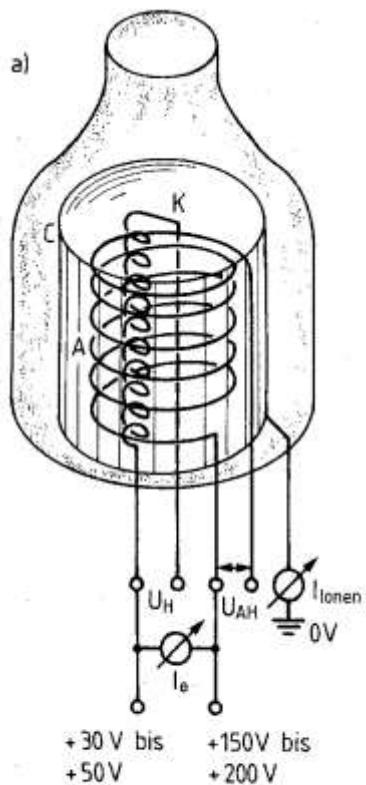


Applied in high vacuum range

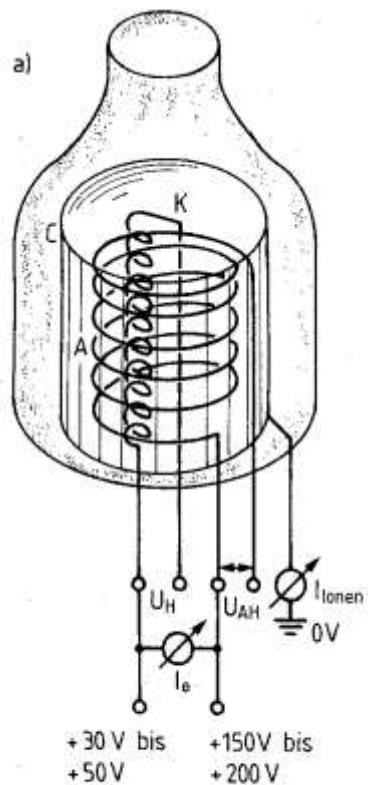


## B: Hot filament manometer

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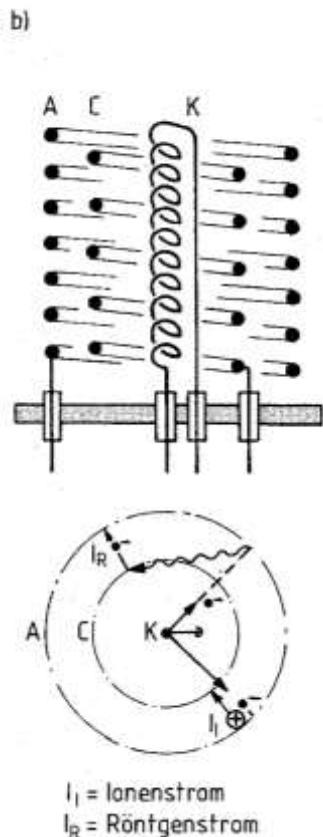
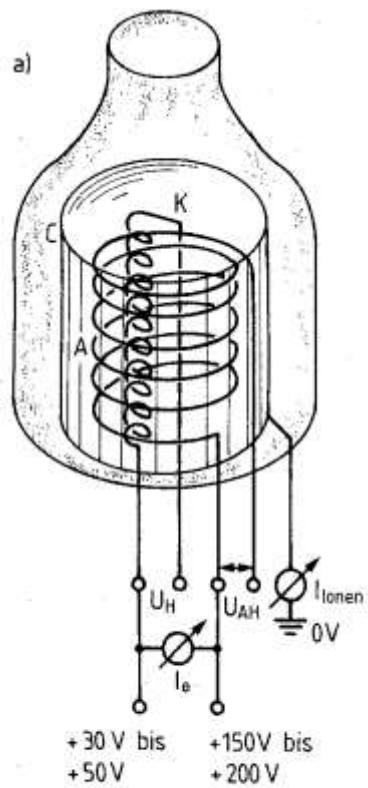


## B: Hot filament manometer



$$P = \text{const.} \cdot I_{\text{ion}} / I_{\text{electron}}$$

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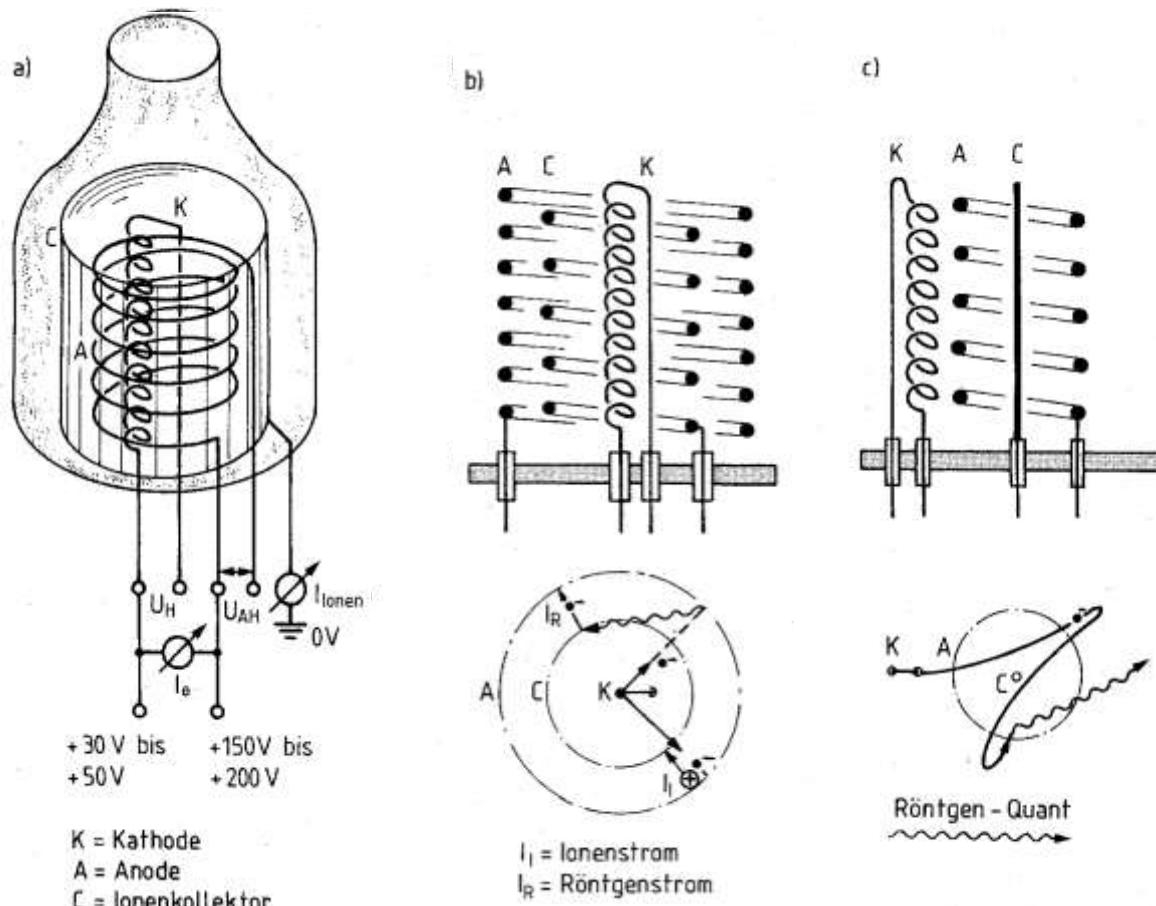


Abb. 12.8 Glühkathoden-Vakuummeter

- Einfache Meßröhre (Glas)
- Hoch- und Feinvakuum-Meßröhre (Eintauchsystem)
- Bayard-Alpert Meßröhre (HV u. UHV) (Eintauchsystem)

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## B: Hot filament manometer

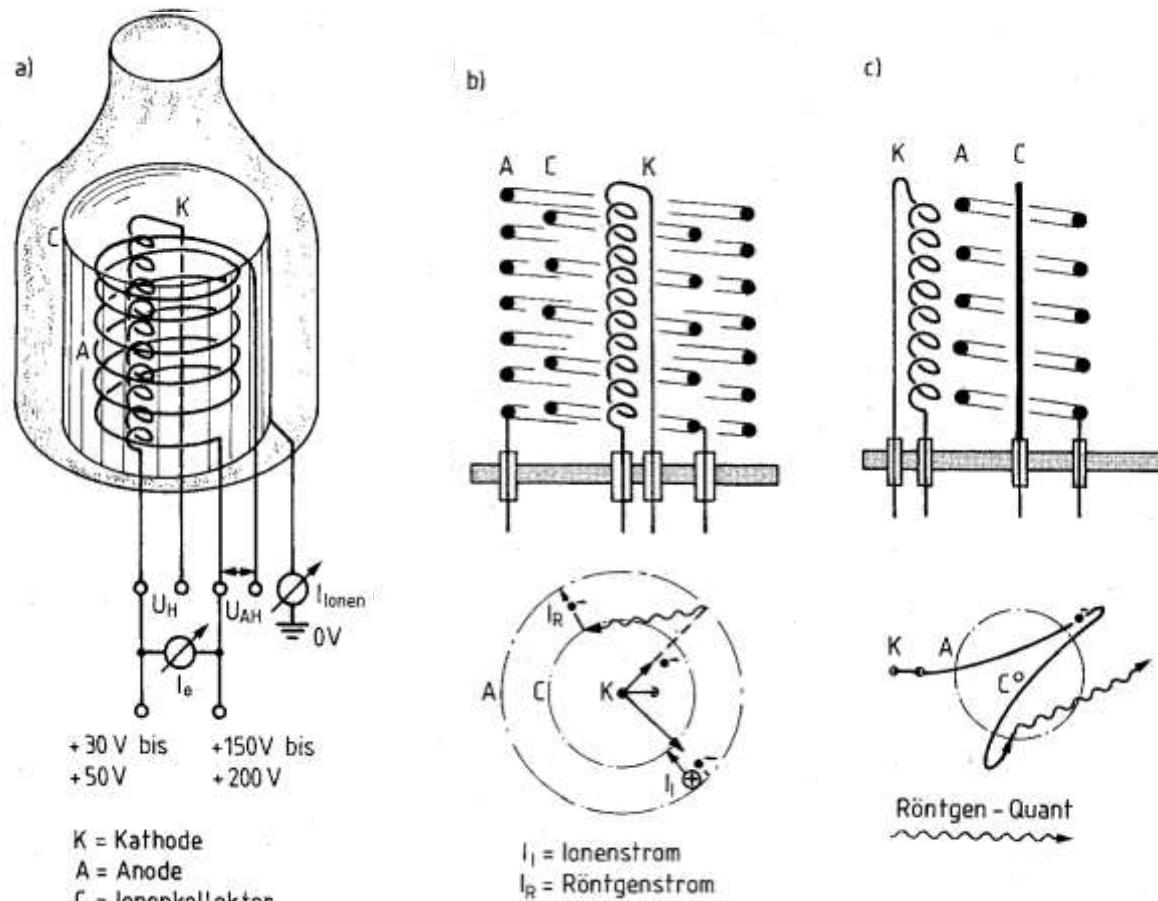
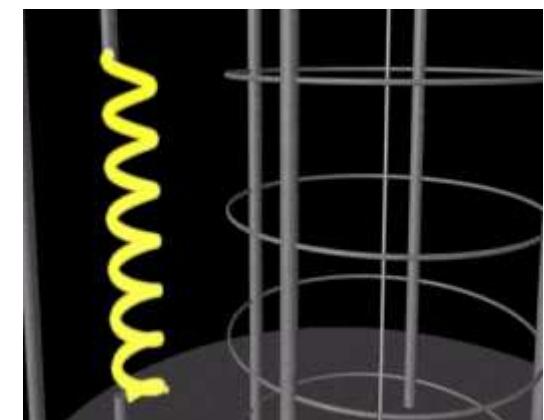


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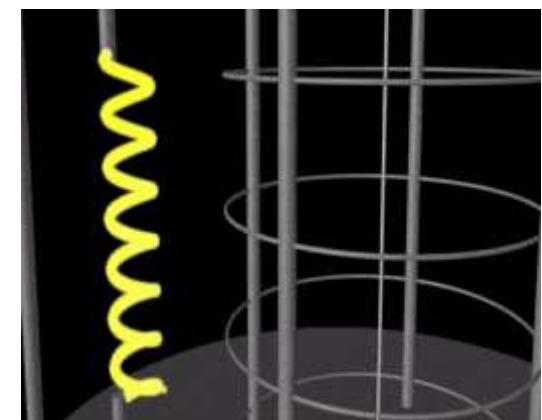
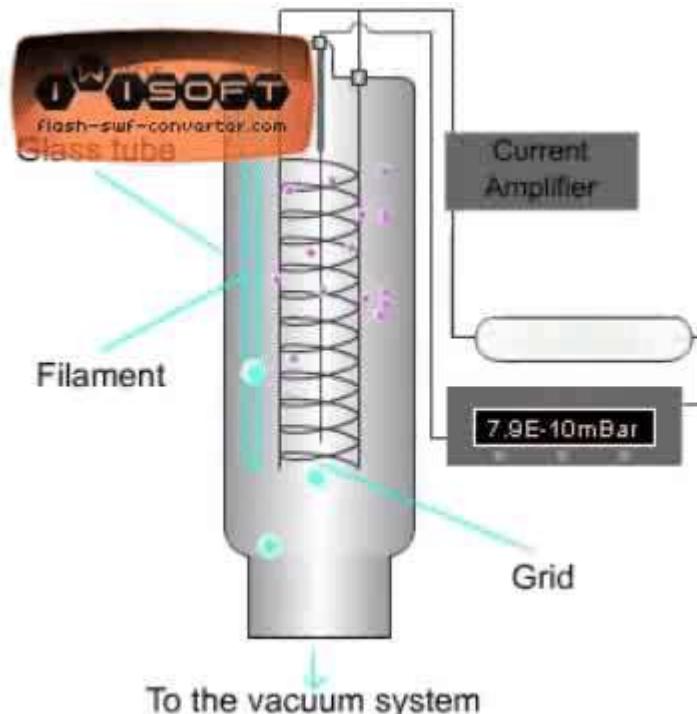
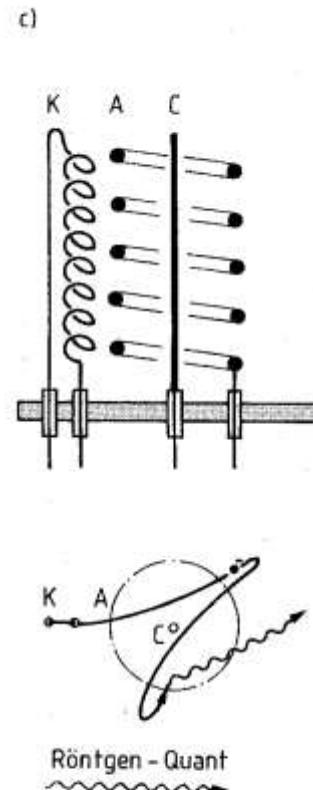
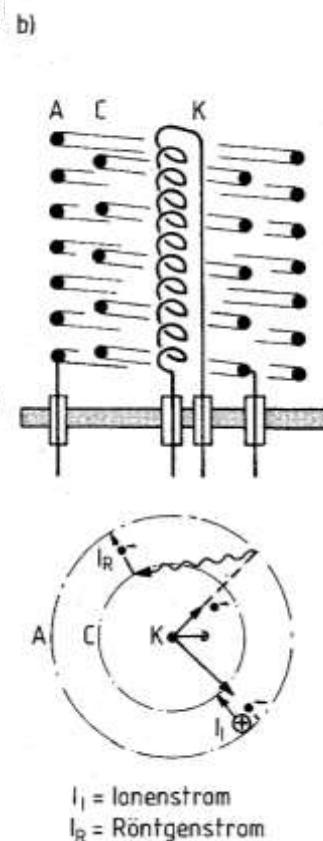
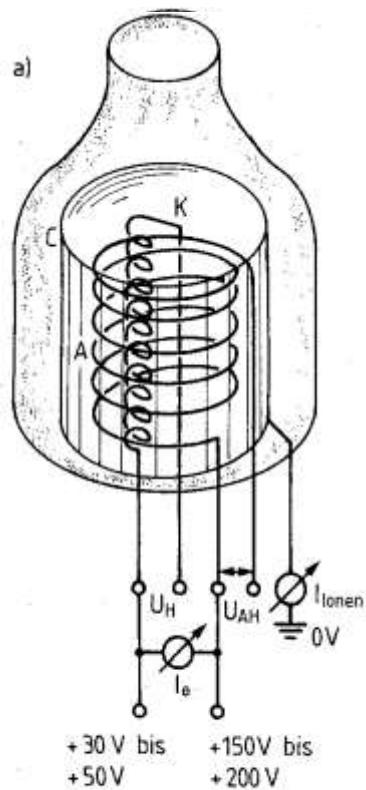
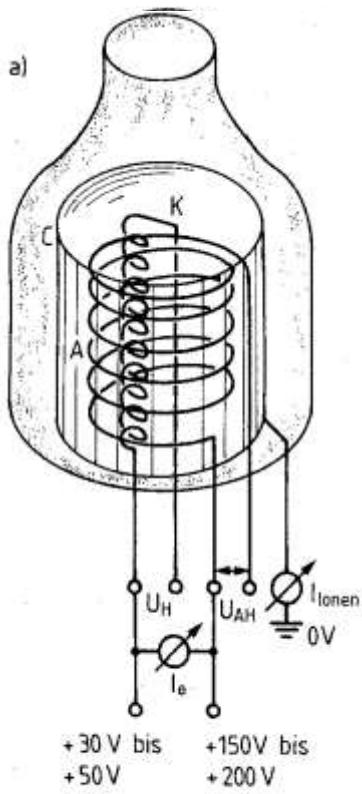


Abb. 12.8 Glühkathoden-Vakuummeter

- a) Einfache Meßröhre (Glas)
- b) Hoch- und Feinvakuum-Meßröhre (Eintauchsystem)
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$$P = \text{const.} \cdot I_{\text{ion}} / I_{\text{electron}}$$

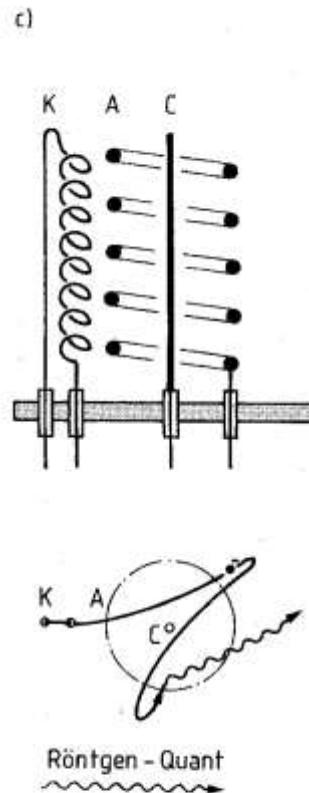
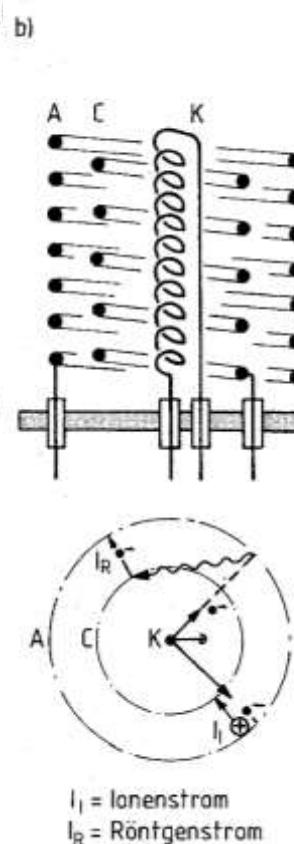
## B: Hot filament manometer



K = Kathode  
A = Anode  
C = Ionenkollektor

Abb. 12.8 Glühkathoden-Vakuummeter

- a) Einfache Meßröhre (Glas)
- b) Hoch- und Feinvakuum-Meßröhre (Eintauchsystem)
- c) Bayard-Alpert Meßröhre (HV u. UHV) (Eintauchsystem)



Covers  
 10<sup>-3</sup> - 10<sup>-8</sup> mBar  
 using Bayard-Alpert setup  
 10<sup>-3</sup> - 10<sup>-12</sup> mBar

<https://www.youtube.com/watch?v=ls6kfQLQWPk>  
<https://www.youtube.com/watch?v=IKKuWeEShM4>  
<https://www.youtube.com/watch?v=RiwCD1TqIIA>  
[https://www.youtube.com/watch?v=6zv\\_YO\\_vwsg](https://www.youtube.com/watch?v=6zv_YO_vwsg)

$$P = \text{const.} \cdot I_{\text{ion}} / I_{\text{electron}}$$

## B: Control unit



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# 5. Vacuum measurement

## 5.1. Pressure measurement

A: Direct or absolute pressure measurement  
= Force / Surface area

!! Independent of the specific gas

Mechanical:  
Bending device

Electrical:  
Baratron

B: Indirect pressure measurement  
= Utilization of density dependent properties  
-Heat conductivity  
-Ionization probability  
-Conductivity

- Pirani
- Penning
- Hot cathode

# 5. Vacuum measurement

5.2 Gas flow

## 5.1. Pressure measurement

A: Direct or absolute pressure measurement  
= Force / Surface area

!! Independent of the specific gas

Mechanical:  
Bending device

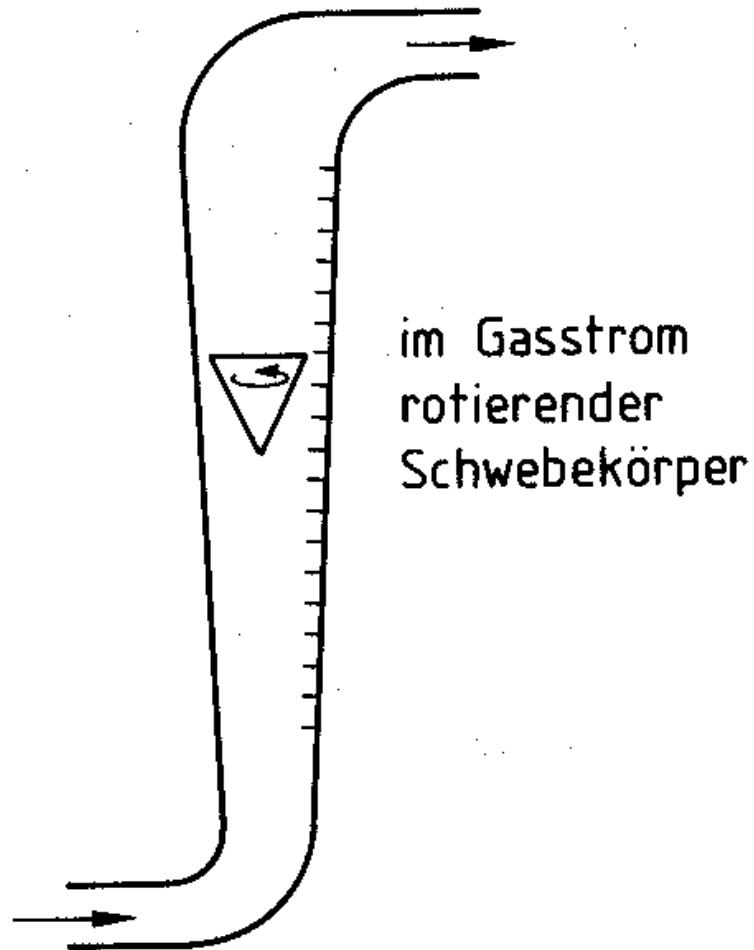
Electrical:  
Baratron

B: Indirect pressure measurement  
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- Heat conductivity
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- Conductivity

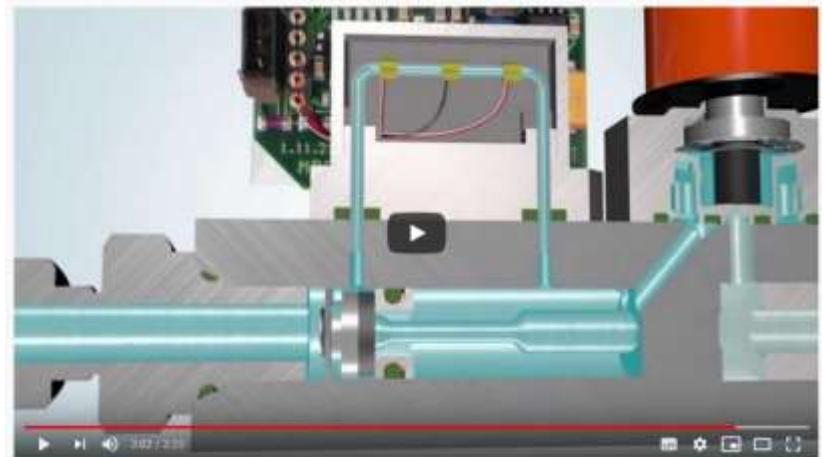
- Pirani
- Penning
- Hot cathode

# Gas flow measurement (mechanical)



<https://www.youtube.com/watch?v=Pz-Mvdc6nf4>

# Gas flow measurement (electronical)



# Gas flow measurement (electrical)

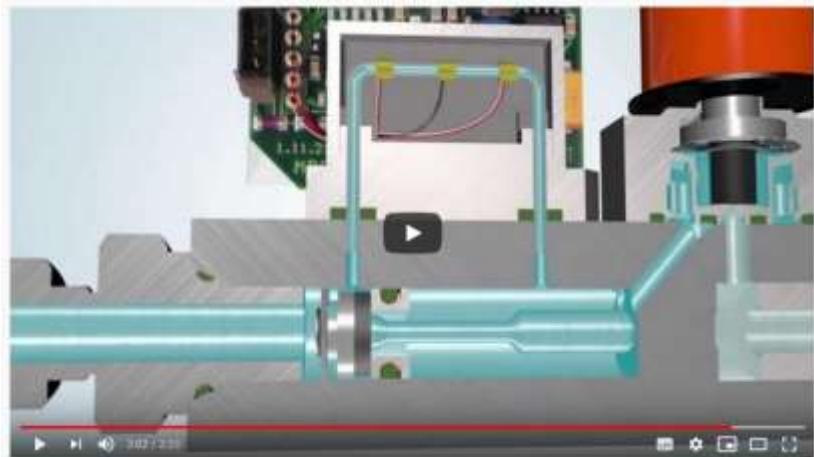
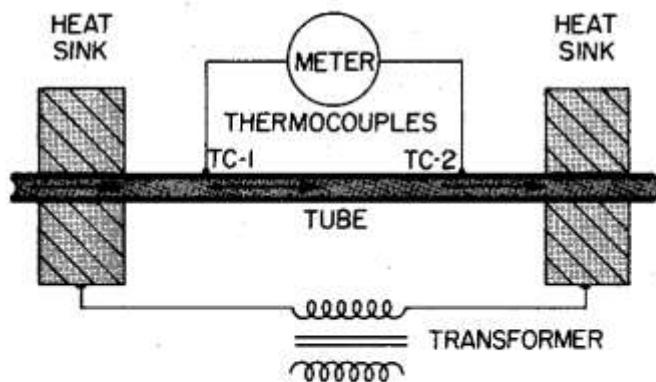


Fig. 9.15. Schematic of a heated tube thermal flowmeter: principle.

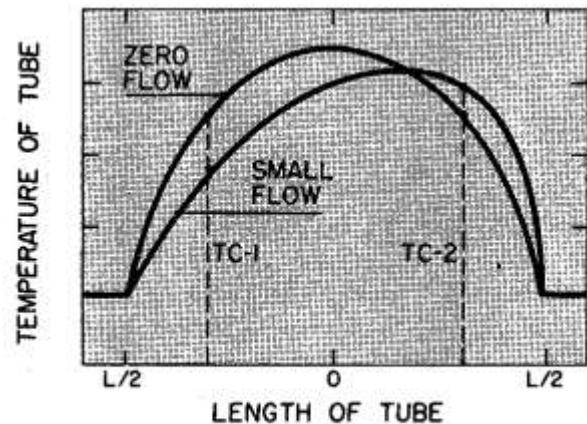


Fig. 9.16. Temperature equilibrium in a thermal flowmeter: principle.

# Gas flow measurement (electronical)

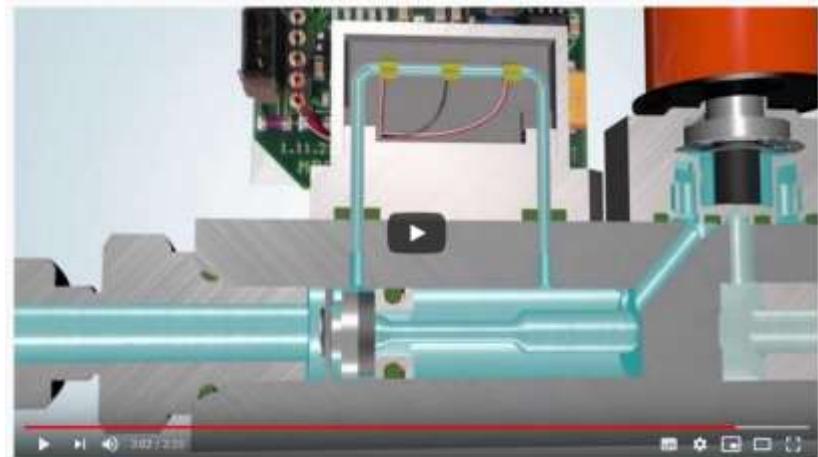
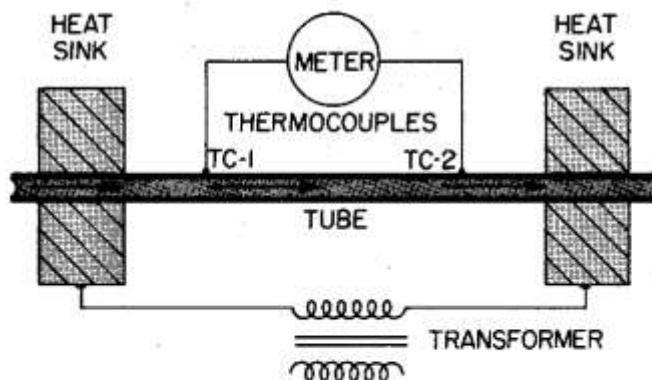


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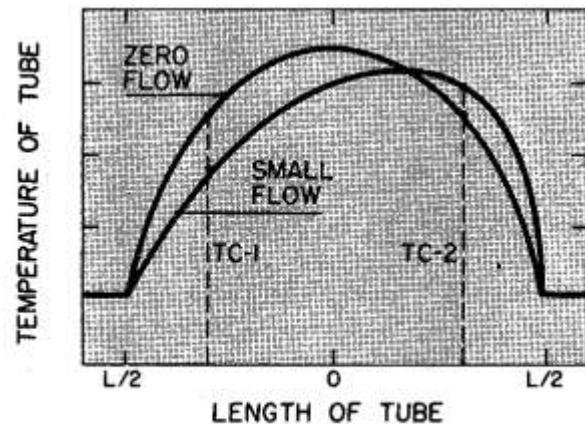


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<https://www.youtube.com/watch?v=G62ma2IFh9o>  
<https://www.youtube.com/watch?v=nPOzuGIblcc>

## 5. Vacuum measurement

5.2 Gas flow

### 5.1. Pressure measurement

A: Direct or absolute pressure measurement  
= Force / Surface area

!! Independent of the specific gas

Mechanical:  
Bending device

Electrical:  
Baratron

B: Indirect pressure measurement  
= Utilization of density dependent properties

- Heat conductivity
- Ionization probability
- Conductivity

- Pirani
- Penning
- Hot cathode

# 5. Vacuum measurement

5.2 Gas flow

5.1. Pressure measurement

5.3 Partial pressure

A: Direct or absolute  
pressure measurement  
= Force / Surface area

!! Independent of the  
specific gas

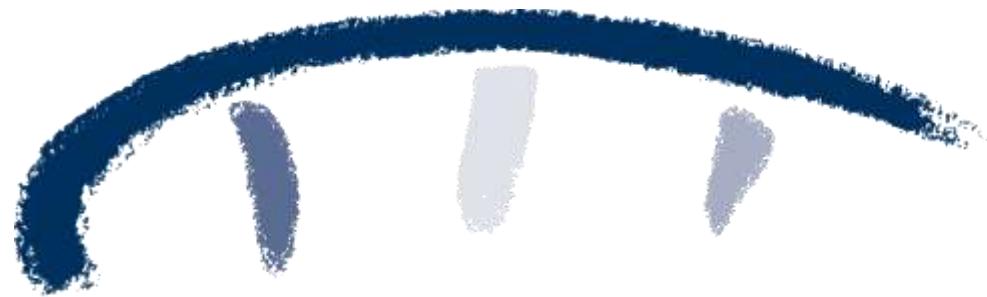
Mechanical:  
Bending device

Electrical:  
Baratron

B: Indirect pressure  
measurement  
= Utilization of density  
dependent properties

- Heat conductivity
- Ionization probability
- Conductivity

- Pirani
- Penning
- Hot cathode



**»Wissen schafft Brücken.«**